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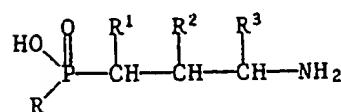
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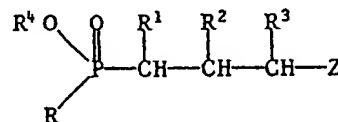
Claims for the following Contracting State: GR.

(54) Substituted propane-phosphinic acid compounds.

(57) Compounds of the formula I



(I),



in which R, R¹, R² and R³ have their previous significances, Z represents -NH₂ and R⁴ denotes a hydroxy-protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl, denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen, and/or any group Z⁰ is converted into -NH₂.

wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, and their salts have GABA_A-antagonistic properties and can be used as GABA_A-antagonists. They are obtained when in a compound of formula II

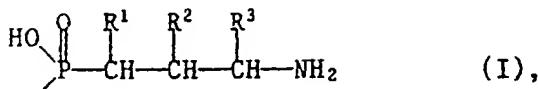
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Description

Substituted Propan -Phosphinic Acid Compounds

The invention relates to compounds of the formula I

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wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, In the case of R¹ and R² is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, and to their pharmaceutically acceptable salts for use for the treatment of the human or animal body, to pharmaceutical compositions containing the same and to compounds of the formula I, provided that R is different from 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl, if one of R¹, R² and R³ represents hydrogen, C₁-C₈-alkyl, C₃-C₆-cycloalkyl, phenyl optionally substituted by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl or C₇-C₁₀-phenylalkyl optionally substituted in the phenyl moiety by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl and the other two of R¹, R² and R³ are hydrogen, and to their salts, provided that salts of compounds of the formula I, wherein R denotes an unsubstituted aliphatic, cycloaliphatic or araliphatic hydrocarbon radical, R¹ and R³ denote hydrogen and R² is hydrogen or alkyl, with bases are different from alkali metal and ammonium salts, and to a process for their manufacture.

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Aliphatic radicals R are, for example, alkyl groups that may be interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and/or substituted by halogen or hydroxy, such as alkyl, alkyl mono-, di- or poly- substituted by halogen and/or hydroxy, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur or alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and substituted by halogen and/or hydroxy, alkenyl groups that may be mono-, di- or poly- substituted by halogen and/or hydroxy, such as lower alkenyl or lower alkenyl substituted by halogen and/or hydroxy, or alkynyl groups, such as lower alkynyl. Aliphatic radicals R₁, R₂ or R₃ are, for example, lower alkyl groups.

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Cycloaliphatic radicals R are, for example, cycloalkyl groups that may be interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and/or substituted by hydroxy, such as cycloalkyl, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur or cycloalkyl substituted by hydroxy. Cycloaliphatic radicals R₁, R₂ or R₃ are, for example, cycloalkyl groups.

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Cycloaliphatic-aliphatic radicals R are, for example, cycloalkyl-lower alkyl groups that may be interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and/or substituted by hydroxy and/or lower alkylthio, such as cycloalkyl-lower alkyl, cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur or cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy or lower alkylthio and/or in the alkylene moiety by hydroxy.

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Araliphatic radicals R and/or R₁, R₂ or R₃ are, for example, phenyl-lower alkyl or naphthyl-lower alkyl radicals that may be substituted in the aryl ring by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl and/or in the lower alkylene moiety by hydroxy, such as phenyl-lower alkyl, phenyl-(1-hydroxy)-lower alkyl, naphthyl-lower alkyl or phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl.

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Aromatic radicals R₁, R₂ or R₃ are, for example, phenyl, naphthyl or phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl.

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In compounds of formula I the group R is bonded to the P-atom via a carbon atom. Alkyl, alkenyl and alkynyl R may contain up to and including 14, preferably 12 carbon atoms and are represented by lower alkyl, lower alkenyl and lower alkynyl. Alkyl R may also be a C₈-C₁₄, e.g. a C₈-C₁₂-alkyl, such as an octyl, nonyl, decyl, undecyl or dodecyl group, e.g. a decyl or dodecyl group.

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Alkyl or alkenyl mono-, di- or poly- substituted by halogen and/or hydroxy is represented by mono- or dihydroxy-lower alkyl, hydroxy-lower alkyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-lower hydroxyalkyl and mono-, di- or polyhalogeno-lower hydroxyalkenyl.

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Alkyl being interrupted by one or two atoms selected from oxygen and sulfur is represented by lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfinyl-lower alkyl, lower alkanesulfonyl-lower alkyl, lower alkoxy-lower alkoxy-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, and lower alkoxy-lower alkylthio-lower alkyl.

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Alkyl being interrupted by one or two atoms selected from oxygen and sulphur and substituted by hydroxy and/or halogen is represented by lower alkoxy-(hydroxy)lower alkyl and lower alkoxy-(halogeno)lower alkyl.

Cycloalkyl is represented by C₃-C₈-cycloalkyl.

Cycloalkyl substituted by hydroxy is represented by 1-hydroxy-C₃-C₈-cycloalkyl.

Cycloalkyl and cycloalkyl in cycloalkyl-lower alkyl, in either case, being interrupted by one or two atoms selected from oxygen and sulfur is represented by oxa-C₃-C₈-cycloalkyl, thia-C₃-C₈-cycloalkyl, dioxa-C₃-C₈-cycloalkyl, dithia-C₃-C₈-cycloalkyl and oxathia-C₃-C₈-cycloalkyl.

Cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy and/or lower alkylthio and/or in the alkylene moiety by hydroxy is represented by lower alkylthiocycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl and lower alkylthiocycloalkyl-(hydroxy)lower alkyl.

The general definitions used herein have the following meaning within the scope of the present invention.

The term "lower" referred to above and hereinafter in connection with organic radicals or compounds respectively, if not defined explicitly otherwise, defines such with up to and including 7, preferably up to and including 4, carbon atoms.

Lower alkyl R is represented by C₂-C₇-alkyl, e.g. ethyl, propyl, isopropyl, butyl, isobutyl, sec.-butyl, tert.-butyl, (2-methyl)butyl, hexyl or heptyl. Lower alkyl other than R denotes, for example, C₁-C₄-alkyl, e.g. methyl, ethyl, propyl, isopropyl, butyl or tert.-butyl.

Lower alkenyl denotes, for example, C₂-C₇-alkenyl, preferably C₃-C₅-alkenyl, carrying the double bond in a higher than the α,β-position, and is e.g. 2-propenyl (allyl), but-3-en-1-yl, (2-methyl)prop-2-en-1-yl (isobutenyl) or (5-methyl)but-2-en-1-yl, but may also carry the double bond in α,β-position and may be, for example, vinyl, prop-1-enyl or but-1-enyl, or may be a C₆- or C₇-alkenyl, such as a hexenyl or heptenyl, group.

Lower alkynyl denotes, for example, C₂-C₇-alkynyl, preferably C₃-C₅-alkynyl, carrying the triple bond in a higher than the α,β-position and is e.g. 2-propynyl (propargyl), but-3-yn-1-yl, but-2-yn-1-yl or pent-3-yn-1-yl.

C₃-C₈-Cycloalkyl preferably had 3 to 6 ring carbon atoms and thus is C₃-C₆-cycloalkyl, e.g. cyclopropyl, cyclobutyl, cyclopentyl or cyclohexyl.

C₃-C₈-Cycloalkyl-lower alkyl preferably has 3 to 6 ring and 1 to 4 chain carbon atoms and is, for example, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, such as cyclopropylmethyl, cyclobutylmethyl or cyclohexylmethyl.

Mono- or dihydroxy-lower alkyl preferably carries one of the hydroxy groups in α-position and is for example, α-hydroxy-C₂-C₇-alkyl, such as α-hydroxy-C₂-C₄-alkyl, e.g. 1-hydroxyethyl, 2-(2-hydroxy)propyl, 1-hydroxybutyl, 2-(2-hydroxy)butyl or 1-(1-hydroxy-2-methyl)propyl, or α,β-dihydroxy-C₂-C₇-alkyl, such as 1,2-dihydroxy-prop-2-yl, but may also carry a single hydroxy group in a higher than the α-position and denote, for example, β-, γ- or δ-hydroxy-C₂-C₇-alkyl, e.g. 3-hydroxypropyl or 2-, 3- or 4-hydroxybutyl.

Hydroxy-lower alkenyl preferably carries the hydroxy group in α-position and the double bond in a higher than the α,β-position and is, for example, corresponding α-hydroxy-C₃-C₅-alkenyl, e.g. 1-hydroxybut-2-enyl.

Mono-, di- or polyhalogeno-lower alkyl is for example, mono-, di- or trifluoro-C₂-C₅-alkyl, e.g. 3,3,3-trifluoro-propyl, 4,4,4-trifluorobutyl, 1- or 2-fluorobutyl or 1,1-difluorobutyl.

Mono-, di- or polyhalogeno-lower alkenyl is, for example, mono-, di- or trifluoro-C₃-C₅-alkenyl, e.g. 2-fluorobut-2-enyl.

Mono-, di- or polyhalogeno-lower hydroxyalkyl and mono-, di- or polyhalogeno-lower hydroxyalkenyl preferably carries the hydroxy group in α-position and the halogen atom(s) in a higher than the α-position and is, for example, corresponding mono-, di- or trifluoro-α-hydroxy-C₂-C₇-alkyl or mono- di- or trifluoro-C₃-C₇-alkenyl, e.g. 2-fluoro-1-hydroxybutyl, 2-fluoro-1-hydroxy-but-2-en-1-yl or 4,4,4-trifluoro-1-hydroxybutyl.

Lower alkoxy-lower alkyl preferably has up to 10 carbon atoms and is, for example, C₁-C₄-alkoxy-C₁-C₄-alkyl, such as C₁-C₃-alkoxy-C₁-C₃-alkyl, e.g. methoxymethyl, ethoxymethyl, 2-methoxyethyl, 2-ethoxyethyl, 3-methoxypropyl or 1- or 2-methoxybutyl.

Lower alkoxy is, for example, C₁-C₄-alkoxy, e.g. methoxy, ethoxy, isopropoxy, propoxy, butoxy, sec.-butoxy or tert.-butoxy.

Lower alkoxy-lower alkoxy-lower alkyl is, for example, C₁-C₄-alkoxy-C₂-C₄-alkoxy-C₁-C₄-alkyl, e.g. 2-methoxyethoxymethyl.

Lower alkylthio-lower alkyl preferably has up to 10 carbon atoms and is, for example, C₁-C₄-alkylthio-C₁-C₄-alkyl, such as C₁-C₃-alkylthio-C₁-C₃-alkyl, e.g. methylthiomethyl, ethylthiomethyl, 2-methylthioethyl, 2-ethylthioethyl or 3-methylthiopropyl.

Lower alkansulfinyl- and lower alkanesulfonyl-lower alkyl preferably has up to 10 carbon atoms and is, for example, C₁-C₄-alkanesulfinyl- or C₁-C₄-alkanesulfonyl-C₁-C₄-alkyl, e.g. ethanesulfinylmethyl or ethanesulfonylmethyl.

Di-lower alkoxy-lower alkyl preferably has up to 15 carbon atoms totally and is, for example, di-C₁-C₄-alkoxy-C₁-C₃-alkyl, such as di-C₁-C₃-alkoxy-C₁-C₃-alkyl, e.g. dimethoxymethyl, diethoxymethyl, dipropoxymethyl, 1,1- or 2,2-diethoxyethyl, diisopropoxymethyl, di-n-butoxymethyl or 3,3-dimethoxypropyl.

Di-lower alkylthio-lower alkyl preferably has up to 15 carbon atoms totally and is, for example, di-C₁-C₄-alkylthio-C₁-C₄-alkyl, such as di-C₁-C₃-alkylthio-C₁-C₃-alkyl, e.g. dimethylthiomethyl, diethylthiomethyl or 1,1- or 2,2-dimethylthioethyl.

Lower alkoxy-(hydroxy)lower alkyl is, for example C₁-C₄-alkoxy-C₁-C₇-(hydroxy)alkyl e.g. 2-(2-hydroxy-3-methoxy)propyl.

Lower alkoxy-(halogeno)lower alkyl is, for example C₁-C₄-alkoxy-C₁-C₇-(halogeno)alkyl e.g. 1-(2-fluoro-1-methoxy)butyl.

Hydroxy-C₃-C₈-cycloalkyl is, for example, 1-hydroxy-C₃-C₆-cycloalkyl, e.g. 1-hydroxycyclobutyl.

Oxa- or thia-C₃-C₈-cycloalkyl preferably has 2 to 6 ring carbon atoms is, for example, 2-oxacyclopropyl

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(oxiranyl), 2- or 3-oxacyclobutyl (oxetanyl), 2- or 3-thiacyclobutyl (thietanyl), 2- or 3-oxacylcopentyl (tetrahydrofuranyl), 2- or 3-thiacyclopentyl (thiolanyl) or 2-oxacyclohexyl (tetrahydropyranyl).

Dioxa-C₃-C₈-cycloalkyl preferably had 3 to 5 ring carbon atoms and carries those two oxygen atoms in 1,3-position to each other, and represents e.g. 1,3-dioxolan-2-yl or 1,3-dioxan-2-yl.

5 Dithia-C₃-C₈-cycloalkyl preferably has 3 to 5 ring carbon atoms and carries those two sulfur atoms in 1,3-position to each other and represents e.g. 1,3-dithiolan-2-yl or 1,3-dithioxan-2-yl. Oxathio-C₃-C₈-cycloalkyl is, for example 1,3-oxathiolan-2-yl or 1,3-oxathioxan-2-yl.

10 C₃-C₈-Cycloalkyl-(hydroxy)lower alkyl preferably has 3 to 6 ring and 1 to 4 chain carbon atoms and is, for example, cyclo-C₃-C₆-alkyl-C₁-C₄-alkyl, e.g. 1-cyclopropyl-1-hydroxymethyl or 1-hydroxy-1-cyclobutylmethyl. Lower alkylthiocycloalkyl-(hydroxy) lower alkyl is, for example, 1-hydroxy-1-(1-methylthiocyclopropyl).

15 Halogen, as a substituent of aromatic and/or araliphatic radicals R¹, R² or R³, is preferably chloro, but may also be fluoro, bromo or iodo.

A phenyl or naphthyl group may have one or more than one, preferably one or two of the same or different substituents as defined hereinbefore. Phenyl- or naphthyl-lower alkyl is e.g. benzyl, naphth-2-ylmethyl, 1- or 2-phenylethyl or 2- or 3-phenylpropyl, each optionally substituted in as described hereinbefore.

20 Salts of the compounds of the formula I are particularly pharmaceutically acceptable salts thereof, such as the corresponding addition salts with acids, as well as the salts with bases. Suitable acids for the formation of said addition salts are, for example, mineral acids, such as hydrochloric, hydrobromic, sulphuric or phosphoric acid, or organic acids, such as organic sulphonic acids, for example, benzenesulphonic, 4-toluenesulphonic or methanesulphonic acid, and organic carboxylic acids, such as acetic, lactic, palmitic, stearic, malic, maleic, fumaric, tartaric, ascorbic or citric acid. Salts with bases are, for example, alkali metal or alkaline earth metal salts, such as sodium, potassium, calcium or magnesium salts, or ammonium salts, such as those with ammonia or suitable organic amines, e.g. diethylamine, di-(2-hydroxyethyl)-amine or tri-(2-hydroxyethyl)-amine. The compounds of the formula I may also form inner salts.

25 Depending on the presence of asymmetric carbon atoms, the compounds of this invention may be in the form of mixtures of isomers, particularly racemates, or in the form of pure isomers, particularly optical anti-podes.

Compounds of the formula I, wherein R denotes an 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl group, one of R¹, R² and R³ denotes hydrogen, C₁-C₈-alkyl, C₃-C₆-cycloalkyl, phenyl optionally substituted by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl or C₇-C₁₀-phenylalkyl optionally substituted in the phenyl moiety by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl and the other two are hydrogen, are known as intermediates for the preparation of corresponding compounds, wherein R denotes hydrogen, and of their salts. Also, salts of those compounds of the formula I, wherein R denotes a hydrocarbon radical, R₁ and R₃ denote hydrogen and R₂ denotes hydrogen or alkyl, are known and have been proposed as flame-protective and surface-active agents.

30 However, compounds of formula I wherein R denotes 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl, one of R¹ and R² represents hydroxy and R³ and the other one of R¹ and R² are hydrogen, the specific compounds of formula I, wherein R is diethoxymethyl, one of R¹ and R² is p-chlorophenyl or methyl and the other one and R³ are hydrogen, and compounds of the formula I, wherein R is a group of the formula -CH(OR')₂ in which R' represents C₁-C₄-alkyl, such as ethyl, propyl, isopropyl or n-butyl, and R¹, R² and R³ are hydrogen, and their salts are hitherto not described in the art and are thus considered novel.

35 The invention therefore relates also to those generically and specifically novel compounds generically known as intermediates and to their pharmaceutically acceptable salts for use in the treatment of the human or animal body and to pharmaceutical preparation containing the same, as well as to compounds of formula I, wherein R is diethoxymethyl, one of R¹ and R² is p-chlorophenyl or methyl and the other one and R³ is hydrogen, or wherein R is a group of the formula -CH(OR')₂ in which R' represents C₁-C₄-alkyl, such as ethyl, propyl, isopropyl or n-butyl, and R¹, R² and R³ denote hydrogen, and to their salts.

40 It has now been found that the compounds of the formula I and their pharmaceutically acceptable salts possess valuable pharmacological properties. They show an effective binding at the GABA_B-receptor and are found to act as antagonists on said receptor. Mechanistically, antagonism at GABA_B receptors may increase the release of fast excitatory amino acid transmitters, i.e glutamate and aspartate, thus improving information processing in the brain. In line with this is the finding that the late inhibitory postsynaptic potential in hippocampus, attributed to a GABA_B mechanism, is shortened by the antagonists thus allowing a faster sequence of nerve impulse transfer.

45 55 On the other hand, chronic treatment with antidepressants and repetitive electroshock have been found to increase the number of GABA_B receptors in rat cerebral cortex. In line with receptor theories, chronic treatment with GABA_B antagonists should result in the same effect. For these and other reasons, GABA_B antagonists may therefore act as antidepressants.

60 The GABA_B antagonists of the present invention react at the GABA_B receptor with IC₅₀ values starting from about 10⁻⁷ M (moles/litre) in rat brain cortex membranes. In contrast to GABA_B agonists, such as baclofen, they do not potentiate the stimulation of adenylate cyclase in rat cerebral cortex slices by noradrenaline, but antagonize the effects of baclofen. The antagonism against baclofen has also been shown in *in vitro* electrophysiological models, such as the penicilline-induced "epileptic" hippocampal slice preparation, where baclofen, at a concentration of 6 µM inhibits "epileptic"-like discharges of pyramidal cells. The compounds of the invention antagonise the effects of baclofen at concentrations from approximately 10 to approximately 10

μM . In vivo, antagonism has been shown by ionophoresis of baclofen on rat cerebral cortex, and systemic application of antagonists in doses of 10 - 100 mg/kg. The muscle relaxant effects of baclofen measured in the rotarod model are also antagonized at doses of about 30 mg/kg ip.

The antagonists do not only show antagonistic effects against baclofen, but have, as theoretically expected (see above), also effects on their own as antagonists of endogenous GABA. Thus the antagonists are active in behavioural models which are established in the art to be indicative of antidepressant, anxiolytic and/or nootropic properties. Compounds of the formula I have been found to be active, after peroral application, in the swim test according to Porsolt, in the Geller test, the one trial, step-down passive avoidance test (one-trial modification) in pretrial and posttrial situations, in the two compartment test and in the complex labyrinth. In addition, in studies on Rhesus monkeys, an increase in playfulness, exploration, social grooming and a reduction of signs of anxiety were observed. Accordingly, the compounds of formula I may be used as nootropic, antidepressive and anxiolytic agents. Of course, they may also be used as baclofen-antidotes.

The invention relates in particular to compounds of the formula I, wherein R has 2 or more carbon atoms and denotes alkyl, alkenyl, alkynyl, alkyl or alkenyl mono-, di- or poly-substituted by halogen and/or hydroxy, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and substituted by halogen and/or hydroxy, cycloalkyl, cycloalkyl substituted by hydroxy, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl-lower alkyl, cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy or lower alkylthio and/or in the alkylene moiety by hydroxy, cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety, phenyl-lower alkyl, naphthyl-lower alkyl or phenyl- or naphthyl lower alkyl ring substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl or naphthyl-lower alkyl, and/or chain-substituted by hydroxy and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl or naphthyl, phenyl or naphthyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy and the remaining one of R¹, R² and R³ is hydrogen, and to their salts, especially pharmaceutically acceptable salts, with the provisos given hereinbefore.

The invention relates, for example, to compounds of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen, sulfur and cycloalkyl, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl or cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety; and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and to their salts, especially pharmaceutically acceptable salts, with the provisos given hereinbefore.

The invention relates, above all, to compounds of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy- lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfonyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower alkyl, phenyl-lower alkyl, phenyl-lower alkyl, phenyl-lower alkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, naphthyl-lower disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, naphthyl-lower alkyl, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxo-, oxathia- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of R¹, R², R³ represents hydrogen, lower alkyl, cycloalkyl having 3 to 6 ring carbon atoms, phenyl, phenyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and to their salts, especially pharmaceutically acceptable salts, with the provisos given hereinbefore.

One embodiment of the invention consists of the sub-group A of compounds of formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, hydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, phenyl-lower alkyl phenyl-lower alkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl or naphthyl-lower alkyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and their hydrogen or, in the case of R¹ and R² is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen.

salts, especially pharmaceutically acceptable salts.

Compounds of subgroup A are, for example, those, wherein R has 2 or more carbon atoms and is, lower alkenyl or lower alkynyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, ph nyl lower alkyl or phenyl lower alkyl substituted in th phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and their salts, especially pharmaceutically acceptable salts.

Another embodiment of the invention consists of the subgroup B of the compounds of formula I, wherein R is represented by lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfinyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxa- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, provided that, if one of R¹ and R² is hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, and the other two of R¹, R² and R³ are hydrogen, R is different from 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl, and their salts, especially pharmaceutically acceptable salts, with the provisos given hereinbefore.

Compounds of subgroup B are, for example, those, wherein R is represented by lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio lower alkyl, lower alkoxy-lower alkylthio-lower alkyl, oxacycloalkyl, thiacycloalkyl, dioxa-cycloalkyl and dithiacycloalkyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and their salts, especially pharmaceutically acceptable salts, with the provisos given hereinbefore.

Preferred are compounds of formula I, wherein R has the meaning defined hereinbefore, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, phenyl or phenyl substituted by halogen or lower alkyl, and the remaining two of R¹, R² and R³ are hydrogen, and their salts, especially pharmaceutically acceptable salts.

Further preferred are compounds of formula I, wherein R is lower alkyl having 2 or more carbon atoms, lower alkenyl or lower alkynyl, R² represents hydrogen, lower alkyl, phenyl or phenyl substituted by halogen or lower alkyl and R¹ and R³ are hydrogen, and pharmaceutically acceptable salts thereof.

Equally preferred is the subgroup B' of compounds of the formula I, wherein R is lower alkoxy-lower alkyl or mono- or dihydroxy-lower alkyl, R² represents hydrogen, lower alkyl, phenyl or phenyl substituted by halogen or lower alkyl and R¹ and R³ are hydrogen, with the provisos given hereinbefore and pharmaceutically acceptable salts thereof.

The invention relates especially to compounds of the formula I, wherein R is C₂-C₁₂-alkyl, such as ethyl, butyl, isobutyl, pentyl or isopentyl, C₂-C₇-alkenyl, such as but-3-enyl, C₂-C₇-alkynyl, such as pent-3-yne, mono- or dihydroxy-C₂-C₇-alkyl, such as 2-(2-hydroxy)-propyl, 2-(1,2-dihydroxy)propyl, 2-(2-hydroxy)butyl or 1-hydroxybutyl, mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkyl, such as 1-hydroxy-4,4,4-trifluorobutyl, α -saturated mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkenyl, such as 1-hydroxy-2-fluoro-but-2-enyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, such as 2-ethoxyethyl, di-C₁-C₄-alkoxy-C₁-C₄-alkyl, such as diethoxymethyl, α -hydroxy-C₃-C₆-cycloalkyl, such as 1-hydroxycyclobutyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, such as cyclopropylmethyl, C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₃-alkyl, such as 1-cyclobutyl-1-hydroxymethyl, or 1-C₁-C₄-alkylthiocycloalkyl- α -hydroxy-C₁-C₄-alkyl, such as (1-methylthiocyclopropyl)-(1-hydroxy)methyl, R² represents hydrogen, hydroxy, C₁-C₄-alkyl, such as methyl, phenyl or phenyl substituted by halogen, such as chloro, or C₁-C₄-alkyl, such as methyl and R¹ and R³ are hydrogen or one of R¹ and R² denotes hydroxy and the other one as well as R³ represents hydrogen, and to their salts, especially pharmaceutically acceptable salts, with the provisos given hereinbefore.

Even more preferred are subgroups A' and/or B' of compounds of formula I, wherein R either is C₂-C₇-alkyl, C₂-C₇-alkenyl or C₂-C₇-alkynyl or denotes C₁-C₄-alkoxy-C₁-C₄-alkyl or di-C₁-C₄-alkoxy-C₁-C₄-alkyl or denotes α -, β -, γ - or δ -hydroxy-C₂-C₇-alkyl or α , β -dihydroxy-C₂-C₇-alkyl, R² represents hydrogen, lower alkyl, phenyl or phenyl substituted by halogen or lower alkyl, and R¹ and R³ are hydrogen, with the provisos given hereinbefore, and pharmaceutically acceptable salts thereof, with the provisos given hereinbefore.

Especially preferred are compounds of the formula I, wherein R denotes C₂-C₇-alkyl, such as ethyl, butyl, isobutyl, pentyl or isopentyl, α -saturated C₃-C₇-alkenyl, such as but-3-enyl, α -saturated C₃-C₇-alkynyl, such as pent-3-yne, α -, β -, γ - or δ -hydroxy-C₂-C₇-alkyl, such as 2-(2-hydroxy)propyl or 1-hydroxybutyl, α , β -dihydroxy-C₂-C₄-alkyl, such as 2-(1,2-dihydroxy)propyl, mono-, di- or trifluoro- α -hydroxy-C₃-C₇-alkenyl, such as 1-hydroxy-4,4,4-trifluorobutyl, α -saturated mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkenyl, such as 1-hydroxy-2-fluoro-but-2-enyl, C₁-C₄-alkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, such as cyclopropylmethyl, α -hydroxy-C₃-C₆-cycloalkyl, such as 1-hydroxycyclobutyl, or C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₄-alkyl, such as

1-cyclopropyl-1-hydroxymethyl, and R¹, R² and R³ represent hydrogen, and to their salts, especially pharmaceutically acceptable salts.

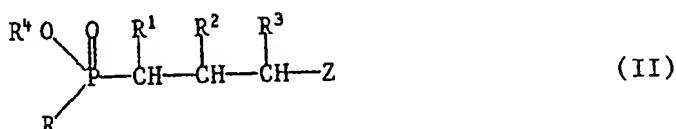
Very especially preferred are subgroups A and/or B of compounds of formula I, wherein R is C₂-C₇-alkyl, C₂-C₇-alkenyl or C₂-C₇-alkynyl, or C₁-C₄-alkoxy-C₁-C₄-alkyl or di-C₁-C₄-alkoxy-C₁-C₄-alkyl and R¹, R² and R³ are hydrogen, and pharmaceutically acceptable salts thereof, with the provisos given hereinbefore.

Most preferred is subgroup(s) A and/or B compounds of formula I, wherein R is C₃-C₇-alkyl and R¹, R² and R³ are hydrogen, and pharmaceutically acceptable salts thereof.

The invention specifically relates to compounds of the formula I described in the Examples herein, and to their salts, especially pharmaceutically acceptable salts.

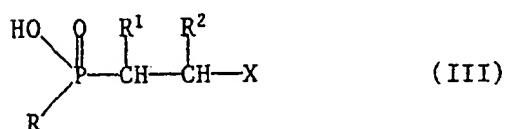
Although salts of compounds of the formula I are included in the above definitions of preferred compounds, the invention predominantly relates to the free compounds of formula I.

The process for the manufacture of compounds of the formula I, is characterized in that
a) in a compound of formula II



in which R, R¹, R² and R³ have their previous significances, Z represents -NH₂ and R⁴ denotes a hydroxy-protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl, denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen and/or any group Z⁰ is converted into -NH₂; or

b) in a compound of the formula III



in which R, R¹ and R² have their previous significances and X is a group capable of being converted into a group of formula -CH(R³)NH₂, the group X is converted into a group of formula



wherein R³ has its previous significance; or

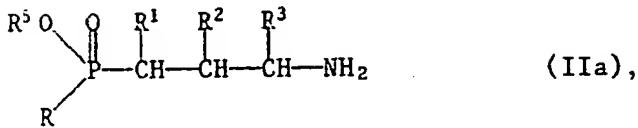
c) a compound of formula I', said compound of formula I' being otherwise identical to a compound of formula I but having one or more carbon-carbon-multiple bond(s) is reduced to produce a compound of formula I, and, if desired, a resulting salt obtained in this process may be converted into the free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual isomers.

Protected hydroxy groups such as groups -OR⁵ present in a protected form in starting materials of the formula II are, for example, etherified hydroxy groups, such as hydroxy groups etherified with aliphatic, cycloaliphatic or araliphatic alcohol, e.g. with a lower alkanol, a cycloalkanol, or a phenyl- or diphenyl-lower alkanol, or hydroxy groups etherified with an aliphatic silanol, e.g. with a tri-lower alkyl silanol. As groups R⁵O-, low r alkoxy, e.g. C₁-C₄-alkoxy, mono- or diphenyl-lower alkoxy, e.g. 1-phenyl- or 1,1-diphenyl-C₁-C₄-alkoxy, and tri-lower alkylsilyloxy, e.g. tri-C₁-C₄-alkyl-, such as trimethylsilyloxy, are especially preferred.

Protected amino groups Z⁰ in starting materials of the formula II are, for example, acylamino groups such as lower alkanoylamino, e.g. acetylamino, or phthalimido, lower alkoxy carbonylamino unsubstituted or substituted by phenyl, e.g. benzoxycarbonylamino or tert-butoxy carbonylamino groups, or 1-aryl-methylamino groups e.g. benzylamino, or 1-phenyl-lower alkylamino, silylated amino groups, such as tri-lower alkylsilylamino or especially bis-(tri-lower alkylsilyl)amino, e.g. bis trimethyl silylamino. A latent amino group Z⁰ may be e.g. nitro or azido.

Preferred compounds of formula II are those having the formula IIa

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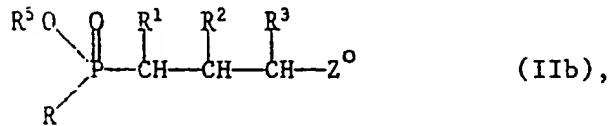


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wherein R⁵ represents a hydroxy-protective group, for example, C₁-C₄-alkyl or C₁-C₄-alkyl substituted by lower alkanoyloxy or by one or two optionally substituted phenyl groups, such as 1-C₂-C₇-alkanoyloxy-C₁-C₄-alkyl, e.g. pivaloyloxymethyl, or 1-phenyl- or 1,1-diphenyl-C₁-C₄-alkyl, e.g. benzyl, or having the formula IIb

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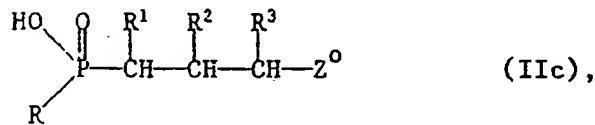


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wherein R⁵ represents a hydroxy-protective group, for example, C₁-C₄-alkyl, C₁-C₄-alkyl substituted by one or two optionally substituted phenyl groups, such as 1-phenyl- or 1,1-diphenyl-C₁-C₄-alkyl, e.g. benzyl, or a silyl group, such as tri-C₁-C₄-alkylsilyl, e.g. trimethylsilyl, and Z⁰ has its previous significance and denotes, for example, C₁-C₇-alkanoylamino, e.g. acetylarnido, phthalimido or bis-silylamino, such as bis(tri-C₁-C₄-alkylsilyl)amino, e.g. bis(trimethylsilyl)amino, or having the formula IIc

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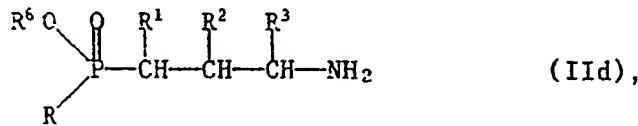
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wherein Z⁰ has its previous significance and denotes, for example, C₁-C₇-alkanoylamino, e.g. acetylarnido, C₁-C₄-alkoxycarbonylamino, e.g. tert.-butyloxycarbonylamino, or phenyl-C₁-C₄-alkoxycarbonylamino, or having the formula IId

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wherein R⁶ denotes an alkali metal or ammonium ion, and wherein in formulae IIa, IIb and IIc R, R¹, R² and R³ have their previous significance or in formula IId R denotes an unsubstituted aliphatic, cycloaliphatic or araliphatic hydrocarbon residue, R¹ and R³ represent hydrogen and R² denotes hydrogen or alkyl.

The replacement of the protective group R⁵ in compounds of formula II, IIa or IIb by hydrogen may be effected by treatment with a suitable nucleophilic reagent such as an alkali metal hydroxide, e.g. sodium hydroxide, or lithium hydroxide, an alkali metal halide, particularly bromide or iodide such as lithium bromide or sodium iodide, thiourea, an alkali metal thiophenolate such as sodium thiophenolate. The replacement reaction may be carried out in the absence or presence of a solvent and, if necessary, while cooling or heating, in a closed vessel and/or under an atmosphere of an inert gas.

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When R⁵ denotes C₁-C₄-alkyl substituted in 1-position by one or two phenyl groups, e.g. when R⁵ is benzyl, the replacement of such a group in compounds of formula II, IIa or IIb by hydrogen may be effected by hydrogenolysis in the presence of a metallic hydrogenation catalyst, or any other suitable procedure.

Alternatively, the replacement of the protective group, e.g. of a silyl or alkyl group, R⁵ in compounds of formula II, IIa or IIb or of an alkali metal or ammonium ion R⁶ in compounds of the formulae II or IId by hydrogen may be effected by treatment with an acid under hydrolytic conditions, especially with a mineral acid such as a hydrohalic acid e.g. hydrochloric acid which is used in dilute or concentrated aqueous form, or by treatment

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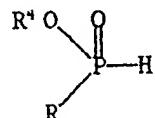
with an organic silyl halide such as trimethylsilyl iodide or bromide, followed by hydrolysis, if necessary. The reaction is preferably conducted at elevated temperature e.g. while refluxing the reaction mixture and, if necessary using an organic diluent, in a closed vessel and/or under an atmosphere of an inert gas. The kind of replacement of the protective group R⁵ depends e.g. on the substituent R present in a compound of formula II which must be retained in converting a compound of formula II to a compound of formula I. Said replacement may be effected e.g. according to the illustrating examples.

Protected amino group or latent amino groups Z⁰ in compounds of formula IIb or IIc may be converted into free amino according to known methods, which are selected according to the characteristics of the protected or latent amino group to be converted into amino, such as solvolytic or hydrogenolytic procedures, for example, hydrolysis in the presence of an acid or a base, acidolysis, e.g. treatment with trifluoroacetic acid, treatment with hydrazine, or hydrogenolysis in the presence of a metallic hydrogenation catalyst, or any other suitable procedure.

Depending on the groups involved, the replacement and conversion operations may be carried out in any sequence or simultaneously by method which are well known per se.

It is preferred that all protecting groups are converted, R⁵ or R⁶ being converted to H and Z⁰ being converted to NH₂, in a single step, by treatment with an acid, preferably a hydrohalic acid, especially hydrochloric acid, under hydrolytic conditions.

The compounds of formula II may be prepared, for example, by various methods according to the nature of the group X in the formula V defined hereinafter, e.g. by reacting, in the presence of a basic catalyst or in the presence of agents forming free radicals, a compound of the formula IV



(IV)

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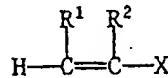
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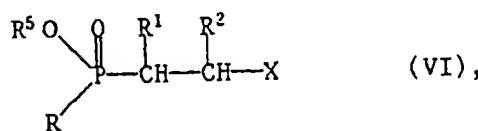
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(V)



in which R¹ and R² have their previous significance and X is a group capable of being converted into a group of formula -CH(R³)-Z, wherein R³ and Z have their previous significances, in order to produce a compound of formula VI



(VI),

wherein R¹, R², R⁵, R and X have their previous significances; and then converting the group X into a group of formula -CH(R³)-Z.

A group X is primarily cyano but may also represent carbamoyl, a group of formula -CH(R³)-Z⁰ (VIa) in which R³ and Z⁰ have their previous significance; or X is a group of formula -C(R³)=Y in which R³ has its previous significance and -C=Y is an optionally functionally modified carbonyl group such as a corresponding ketal or thioketal group, including a corresponding cyclic group.

When, in a compound of formula IV R⁴ has its previous significance and, in the compound of formula V, X is an activating group Xa such as cyano or -C(R³)=O, then either a basic catalyst or a free radical catalyst may be employed. When, however, the same compounds of formula IV are reacted with compounds of formula V in which X is e.g. a residue of formula -CH(R³)-Z⁰, then free radical catalysts are required.

A basic catalyst used in the first step may be e.g. an alkali metal C₁-C₄-alkoxide, for example, a sodium or potassium C₁-C₄-alkoxide, in particular sodium methoxide, sodium ethoxide or potassium t-butoxide, an

alkaline or alkaline earth metal fluoride, such as potassium fluorid or caesium fluoride, or an alkali metal hydride, such as sodium hydride. The reaction may be effected with or without the use of an added solvent.

If a solvent is added, this is preferably an alcohol, in particular a C₁-C₄-alkanol corresponding to the alkoxide used as basic catalyst. The reaction temperature may vary from 0°C to the boiling point of any added solvent.

Agents forming free radicals are, for example, compound convertible into free radicals by ionizing or ultra-violet radiation, preferably peroxy compounds, such as inorganic peroxy compounds, e.g. hydrogen peroxide or ammonium persulfate, or organic peroxides, e.g. benzoyl peroxide or tert-butyl peroxide, or organic azo compounds, e.g. azo-bis-isobutyronitrile. Reactions involving free radical-forming agents may be conducted in the optional presence of a solvent and, if necessary, while cooling or heating, in a closed vessel and/or in an atmosphere of an inert gas.

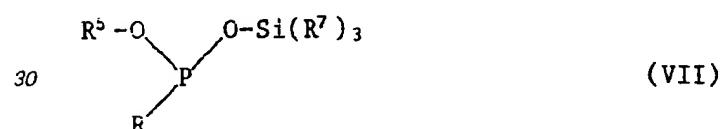
The conversion of a group X into the group -CH(R³)-Z is carried out according to known methods. Cyano and carbamoyl are converted into aminomethyl by reduction, cyano, for example, by hydrogenation in the presence of a suitable catalyst, e.g. Raney nickel and of a solvent, such as ethanol, which may preferably contain ammonia, and carbamoyl, for example, by treatment with a suitable hydride reducing agent, such as borane in tetrahydrofuran.

The conversion of a group X in the compounds of formula VI in which X is a group -C(R³)=Y, in which Y is oxygen, into the group of the formula -CH(R³)-Z is carried out by known reductive amination procedures, e.g. treatment with sodium cyanoborohydride in the presence of ammonium acetate in a suitable solvent, such as dioxane, and while cooling, e.g. at about 0°C.

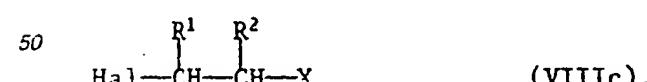
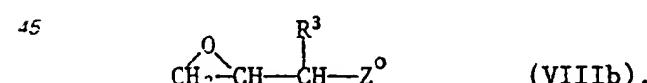
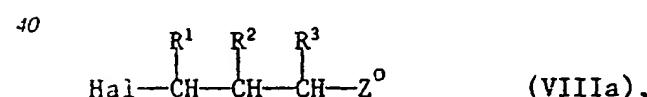
The compounds of formula IV are either known or they may be prepared by methods as described hereinbefore. Specific examples of compounds of formula IV include: iso-propyl (ethyl)phosphonite, isopropyl (n-propyl)phosphonite, iso-butyl (n-butyl)phosphonite, iso-butyl (iso-propyl)phosphonite, iso-butyl (iso-butyl)phosphonite and iso-butyl (sec.-butyl)phosphonite.

Likewise, compounds of formula V are either known or can be obtained by methods which are well known.

Alternatively, a compound of the formula VII



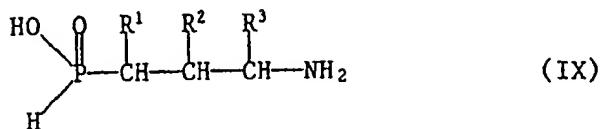
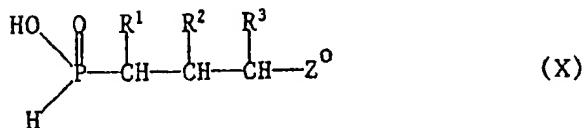
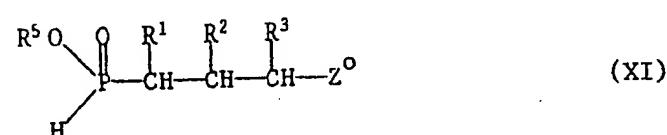
35 in which R⁵ is C₁-C₄-alkyl or C₁-C₄-alkyl substituted by one or two phenyl residues or an additional group -Si(R⁷)₃, each R⁷, independently, is C₁-C₆-alkyl, preferably C₁-C₂-alkyl, particularly methyl, the groups R⁵ and R⁷ being the same or different, can be reacted with a compound of the formulae



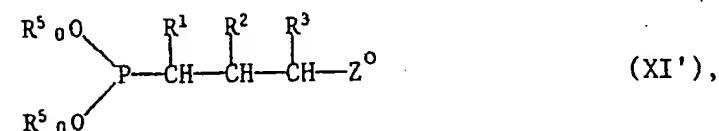
in which R¹, R², R³, Z⁰ and X have their previous significances, X being primarily cyano or a group of the formula -C(R³)=Y and Hal stands for halogen, such as iodo, bromo or chloro. The reaction with an epoxide of formula VIIIb is advantageously carried out in the presence of a mild Lewis acid, such as anhydrous zinc chloride, whilst the reactions with halides of formulae VIIIa or VIIIc are preferably carried out under the conditions of the Arbusov method, e.g. at a reaction temperature ranging from room temperature to an elevated temperature, e.g. 160°C, while removing the trialkyl silyl halide formed in the reaction.

65 The compounds of formula IIb and/or IIc may also be prepared starting from and reacting, e.g. acylating a

compound of formula IX

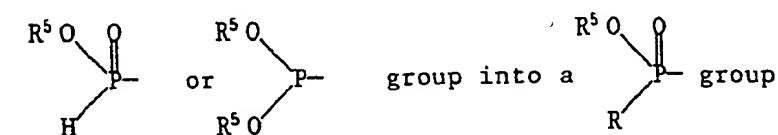
wherein R¹, R² and R³ have their previous significances to give a compound of formula Xwherein R¹, R² and R³ have their previous significance and Z⁰ is an e.g. acylated amino group and, subsequently, protecting the (acid) hydroxyl group in the compound of formula X to produce a compound of formula XIwherein R¹, R², R³ and Z⁰ have their previous significances and R⁵O denotes protected, e.g. esterified, hydroxy. Alternatively, the starting material of formula IX can be reacted with a silylating agent, such as a hexa-lower alkyl silazane or a tri-lower alkyl halogenosilane, e.g. with hexamethyldisilazane, or with trimethylchlorsilane in the presence of triethylamine, to produce a compound of formula

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wherein R⁵₀ a group R⁵ being denotes tri-lower alkylsilyl, e.g. trimethylsilyl, and Z⁰ denotes bis(tri-lower alkylsilyl)amino, such as bis(trimethylsilylamino).

The intermediate of the formula XI or XI' is then reacted with a compound capable of converting the

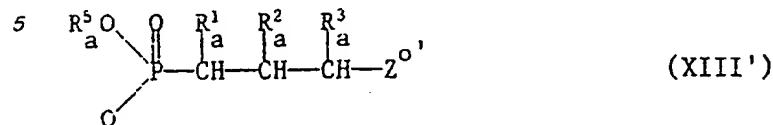
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wherein R has its previous significance to produce a compound of formula IIb, in which R⁵ has its previous significance. Thus, the intermediate of the formula XI may be reacted with an aliphatic, cycloaliphatic, cycloaliphatic or araliphatic aldehyde or ketone, for example, of the formula R'-C(R'')=O (XIIa) which corresponds to a group R of the formula R'-CH(R'')(OH)-, with an terminally unsaturated aliphatic, cycloaliphatic or araliphatic compound R''-H (XIIb), wherein R'' is a group otherwise identical to R but has at least one additional terminal double bond, or in the presence of a basic condensation agent, such as a tri-lower alkyl amine, e.g. of N-ethyl-N,N-diisopropyl-amin, with a corresponding halide, e.g. a low r alkyl halid of the formula R-Hal (XIIc, Hal=halogen), preferably under basic conditions.

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The starting materials of formula IX and their production have been described in U.S. 4656298 which discloses the replacement, in a compound of formula XIII'



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wherein one of R¹, R² and R³ is hydrogen, C₁-C₈-alkyl, C₃-C₆-cycloalkyl, phenyl optionally substituted by halogeno, C₁-C₄-alkyl, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or CF₃, or is C₇-C₁₀-phenylalkyl optionally substituted in the phenyl moiety by halogeno, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or CF₃, and the other two are hydrogen, Z⁰ is a protected amino group, R^a is hydrogen, C₁-C₄-alkyl or an alkali metal or ammonium cation and Q is hydrogen or a protecting group,
replacing to group R⁵, when it is alkyl, by hydrogen or by an alkali metal or ammonium cation;
replacing the group Q when it is a protecting group, by hydrogen; and converting Z⁰ into NH₂, to produce a compound of formula IX.

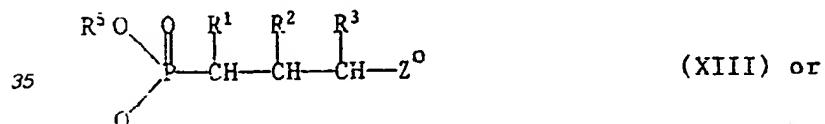
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In U.S. 4656298, protecting groups Q e.g. -C(C₁-C₄-alkyl)(OR^a)(OR^b), preferably -CH(OR^a)(OR^b in which R^a and R^b are C₁-C₄-alkyl, especially -CH(OC₂H₅)₂ and/or a C₁-C₄-alkyl group R⁵_a, may be replaced by hydrogen by treating the compound of formula XIII' with an acid under hydrolytic conditions; or by treatment with an organic silyl halide such as trimethyl silyl iodide or bromide, followed by hydrolysis. It is preferred in U.S. 2656298, to replace protecting groups Q and R⁵_a by hydrogen, and convert Z⁰ into NH₂ in compounds of formula XIII', in a single step, with an acid under hydrolytic conditions.

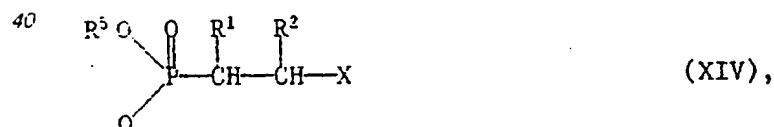
This known method has the disadvantage that, under the drastic reacting conditions disclosed, the hydroxy-protecting group R⁵_a and the amino-protecting group are removed simultaneously with the protecting group Q.

It has now been found that in a compound of formula XIII or XIV

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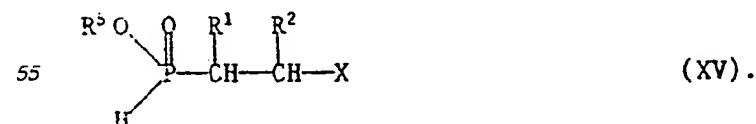


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wherein R¹, R², R³, R⁵, Q, X and Z⁰ have their previous significance, the respective protecting groups R⁵ and Z⁰, or R⁵ and X, respectively, are retained, when the compound of formula XIII or XIV is treated with a protic anhydrous medium, to produce a compound of formula XI, or a compound of formula

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60 Examples of such protic anhydrous media include:
anhydrous hydrogen chloride gas, or an anhydrous medium may be generated from an organic compound having one or more Si-Cl bonds together with an agent e.g. an alkanol capable of cleaving the Si-Cl bond, to produce an anhydrous protic medium in situ.

65 Preferred anhydrous protic media include therefore trimethyl silyl chloride in technical chloroform which contains ethanol.

This novel route has the advantage that re-protecting steps, e.g. IX → X and X → XI, necessary for known routes, are avoided.

The invention, therefore, also relates to a process for the manufacture of compounds of the formula

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wherein X denotes cyano, carbamoyl or a group of the formulae -CH(R³)-Z⁰ (XVa) or -C(R³)=Y (XVb) in which Z⁰ denotes a protected or latent amino group as specified hereinbefore, Y denotes an optionally acetalised, thioacetalised, ketalised or thioketalised oxo group, one of R¹, R² and R³ is hydrogen, hydroxy, C₁-C₆-alkyl, C₃-C₆-cycloalkyl, phenyl optionally substituted by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl or is C₇-C₁₀-phenylalkyl optionally substituted in the phenyl moiety by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl and the others of R¹, R² and R³ are hydrogen, and R^{5b} denotes a C₁-C₄-alkyl radical, characterised in that a compound of the formula

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wherein R¹, R², R³, R^{5b} and X have the meanings given hereinbefore and Q' denotes a group of the formula -C(R⁸)-C(OR⁹)(OR¹⁰) (XIVa) in which R⁸ denotes lower alkyl and R⁹ and R¹⁰, independently of one another, represent lower alkyl or together represent lower alkylene, is treated with an anhydrous protic medium, and to compounds of formula XV, whenever manufactured by this process or an obvious chemical equivalent, thereof.

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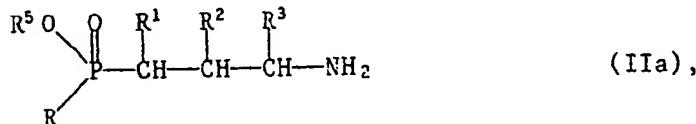
The novel process is carried out at a temperature ranging from -80°C to 100°C, preferably from 0°C-50°C.

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While the relative molar ratios of the reactants i.e. of reactant XIV to the organic silyl chloride, used may vary within a wide range, it is preferred to use molar ratios ranging from 1 to 2 molar equivalents of the latter, per mole equivalent of XIV.

In a preferred embodiment of process variant a) for the manufacture of compounds of formula I a compound of the formula IIa

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wherein R⁵ denotes lower alkyl and R, R¹, R² and R³ have their previous significances which may be obtained, for example, according to the reaction sequences

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IV + V → VI → IIa;

VII + VIIIC →

VI → IIa;

VII + VIIIB → (IIb) → IIa or

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XIV → XV → VI → IIa;

is subjected to basic or acidic hydrolysis or is treated with a tri-lower alkyl halogenosilane.

The combined process characterised by the reaction sequence

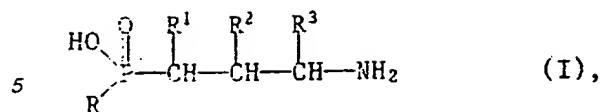
XIV → XV → VI → IIa → I

is a novel and advantageous route to compounds of formula I.

The invention, therefore also relates to a process for the manufacture of compounds of the formula I

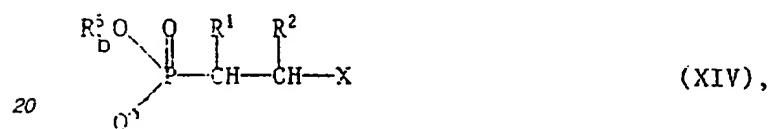
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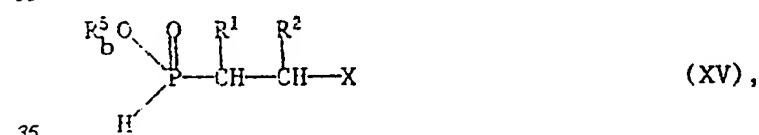
10 wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen, or in the case of R¹ and R², is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, and to their salts, characterised in that a compound of the formula

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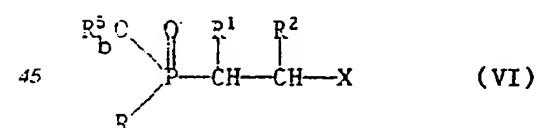


25 wherein R^{5b} denotes a C₁-C₄-alkyl radical, X denotes cyano, carbamoyl or a group of the formulae -CH(R³)-Z⁰ (XVa) or -C(R³)=Y (XVb) in which Z⁰ denotes a protected or latent amino group as specified hereinbefore, Y denotes an optionally acetalised, thioacetalised, ketalised or thioketalised oxo group and Q' denotes a group of the formula -C(R⁸)-(OR⁹)(OR¹⁰) (XIVa) in which R⁸ denotes lower alkyl and R⁹ and R¹⁰, independently of one another, represent lower alkylene and R¹, R² and R³ have the meanings given hereinbefore, is treated with an anhydrous protic medium, the resulting compound of the formula

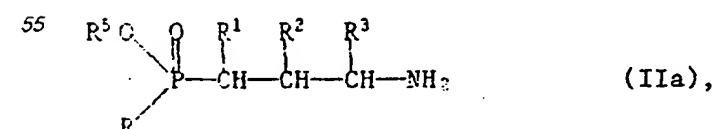
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40 wherein R¹, R², R^{5b} and X have their previous significances is reacted with a compound of the formulae R'(CR'')=O (XIIa), R''-H (XIIb) or R-Hal (XIIc) wherein R, R', R'' and R''' have their previous significances, in the resulting compound of formula VI



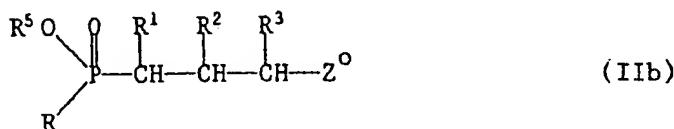
50 wherein R¹, R², R^{5b}, R and X have their previous significances; the group X is converted into a group of formula -CH(R³)-NH₂ (IIa') and the resulting compound of formula IIa



60 wherein R, R¹, R², R³ and R^{5b} have their previous significances is converted into the corresponding compound of formula I.

In this context, X is preferably cyano, the organic silyl chloride is preferably one of formula XVI, the intermediate XV is preferably reacted with a compound XIIc and/or the conversion of the cyano group into the -CH₂NH₂ group is preferably effected by hydrogenolysis.

In another preferred embodiment of process variant a), a compound of the formula IIc



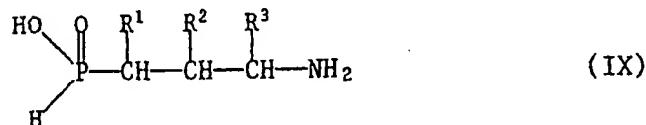
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wherein R, R¹, R², R³, R⁵ and Z⁰ have their previous significances, which may be prepared, for example, via the reaction sequences

Ix → X → XI → IIb or

Ix → XI' → IIb,

is subjected to basic or acidic hydrolysis or is treated with a tri-lower alkyl halogenosilane followed by aqueous workup. Advantageously, a compound IIb, wherein R⁵ denotes tri-lower alkylsilyl, Z⁰ denotes bis(lower alkylsilyl)amino and R¹, R² and R³ have their previous significances, is formed in situ by reacting a compound of the formula



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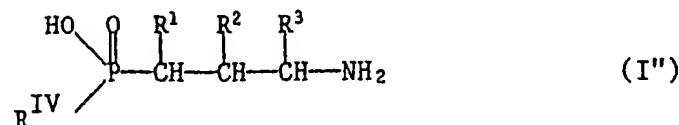
with a silylating agent and subsequently, preferably under basic conditions, with a compound of the formula R-Hal (XIIb; Hal = halogen) and de-protected according to the invention, when worked up under protic, e.g. aqueous or aqueous/alcoholic conditions.

The conversion of the group X into a group of formula -CH(R³)-NH₂ according to process variant b) may be effected by any of the method described hereinbefore, e.g. by a variation of the conversion of compounds of formula VI into compounds of formula II.

The reaction is carried out according to known methods, in the absence or presence of a solvent, which may also serve as a reagent, if necessary, while cooling or heating, in a closed vessel and/or in the atmosphere of an inert gas.

The starting materials of the formula III may be prepared, for example, from compounds of the formula VI by converting the group R⁵O- into hydroxy, the reaction being carried out according to the previously described procedure, e.g. by acidic hydrolysis, such as by treatment with an aqueous mineral acid, e.g. hydrochloric acid, or by treatment with a nucleophilic reagent.

In process variant c), a compound of formula I' may have its unsaturation within the substituent R such that it is e.g. of the formula I"



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In this case R^{IV} may be selected from lower alkenyl, lower alkanedienyl or lower alkynyl, to produce a compound of formula I, wherein R is lower alkyl, or phenyl to produce a compound of formula I wherein R is cyclohexyl.

The reduction may be effected by any suitable reducing agent, such as hydrogen in the presence of a catalyst, for the reduction of aryl e.g. Nishimura catalyst and for the reduction of aliphatic multiple bonds e.g. Palladium on charcoal, in the presenc or absence of a solvent and at room temperatur or elevated temperature.

The compounds of formula I' may be produced according to any of the m thods described herein for the manufacture of compounds of formula I starting from starting materials having the respective unsaturated substituents. Furthermore, compounds of formula I'' may also be obtained starting from the corresponding R^{IV}-dichlorophosphine by reaction with lower alkanol, such as ethanol, and a tri-lower alkylamine, such as triethylamine, reacting the resulting R^{IV}-phosphorous acid ester with a compound of formula HC(R¹)=C(R²)-X (V; X = e.g. CN) and converting the group X into the corresponding group -CH(R³)-NH₂.

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The above-mentioned reactions are carried out according to standard methods, in the presence or absence of diluents, preferably such as are inert to the reagents and are solvents thereof, of catalysts, condensing or said other agents respectively and/or inert atmospheres, at low temperatures, room temperature or elevated temperatures preferably near the boiling point of the solvents used, at atmospheric or super-atmospheric pressure.

Compounds of the formula I obtainable according to the process of the invention may be interconverted into another.

Thus, compounds of formula I, wherein R is substituted by hydroxy, and/or R¹ or R² denotes hydroxy, can be converted into the corresponding hydroxy-free compounds, for example, by reacting with thiocarbonnyldimidazole and treating the resulting imidazolylthiourethane in the presence of a radical-initiator, such as azoisobutyronitrile, with a tri-lower alkylstannane, e.g. with (C₄H₉)₃SnH, for example in benzene at 60 to 80°C.

Also double and/or triple bonds present in the group R may be reduced to single bonds, triple bonds also to double bonds to yield the corresponding less unsaturated compound of formula I.

The invention further includes any variant of the present processes, in which an intermediate product obtainable at any stage thereof is used as starting material and the remaining steps are carried out, or in which the starting materials are formed under the reaction conditions, or in which the reaction components are used in the form of their salts or optically pure antipodes. Whenever desirable, the above processes are carried out after first suitably protecting any potentially interfering reactive functional groups, e.g. as illustrated herein.

Advantageously, those starting materials should be used in said reactions that lead to the formation of those compounds indicated above as being preferred.

The invention also relates to novel starting materials and processes for their manufacture. Thus, compounds of formula IIa and IIc except those, wherein R¹ and R³ denote hydrogen, R² is hydrogen or alkyl and R denotes an unsubstituted aliphatic cycloaliphatic or araliphatic radical, or one of R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical and the other two of R¹, R² and R³ denote hydrogen and R is -CH(O-C₁-C₄ alkyl)₂ or -C(C₁-C₄ alkyl)(O-C₁-C₄ alkyl)₂ and compounds of formula IIb except those in which one of R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical and the other two of R¹, R² and R³ denote hydrogen and R is -CH(O-C₁-C₄ alkyl)₂ or -C(C₁-C₄ alkyl)(O-C₁-C₄ alkyl)₂, are new. Those new compounds form further aspects of the invention.

Depending on the choice of starting materials and methods, the new compounds may be in the form of one of the possible isomers, for example, as diastereomers, as optical isomers (antipodes), as racemates, or as mixtures thereof.

In case diastereomeric mixtures of the above compounds or intermediates are obtained, these can be separated into the single racemic or optically active isomers by methods in themselves known, e.g. by fractional distillation, crystallization or chromatography.

The racemic products of formula I or basic intermediates can be resolved into the optical antipodes, for example, by separation of diastereomeric salts thereof, e.g., by the fractional crystallization of d- or l-(tartrate, dibenzoyltartrate, mandelate or camphorsulfonate) salts.

Advantageously, the more active of the antipodes of the compounds of this invention is isolated.

Furthermore, the compounds of the invention are either obtained in the free (Zwitterion-) form, or as a salt thereof. For example, any resulting free compound can be converted into a corresponding acid addition salt, preferably with the use of a pharmaceutically acceptable acid or anion exchange preparation, salts with bases by treatment of the free compounds with bases or suitable cation exchange techniques, or resulting salts can be converted into the corresponding free compounds, for example the acid addition salts, with the use of a stronger base, such as a metal or ammonium hydroxide, or any basic salt, e.g., an alkali metal hydroxide or carbonate, or a cation exchange preparation and the salts with bases by treatment with suitable acidic reagents. These or other salts, for example, the picrates, can also be used for purification of the compounds obtained; the compounds are then first converted into salts. In view of the close relationship between the free compounds and the compounds in the form of their salts, whenever a compound is referred to in this context, a corresponding salt is also intended, provided such is possible or appropriate under the circumstances and the term "salts" shall, if desired also include the free compounds, where appropriate according to meaning and purpose.

The compounds, including their salts, may also be obtained in the form of their hydrates, or include other solvents used for the crystallization.

The present invention also relates to the use of the compounds of the invention for the preparation of pharmaceutical compositions, especially pharmaceutical compositions having selective GABA_B-antagonistic activity which can be used for the treatment of e.g. cognitive and memory disorders, depressive states of mind and anxieties.

The pharmaceutical compositions according to the invention are those suitable for enteral, such as oral or rectal, transdermal and parenteral administration to mammals, including man, for the treatment of diseases responsive to GABA_B-receptor blocking as given above, comprising an effective GABA_B-receptor blocking amount of a compound of the invention, alone or in combination with one or more pharmaceutically acceptable carriers.

The pharmacologically active compounds of the invention are incorporated into pharmaceutical compositions comprising an effective amount thereof in conjunction or admixture with excipients or carriers suitable for either enteral or parenteral application.

Preferred are tablets and gelatin capsules comprising the active ingredient together with a) diluents, e.g. lactose, dextrose, sucrose, mannitol, sorbitol, cellulose and/or glycine; b) lubricants, e.g. silica, talcum, stearic acid, its magnesium or calcium salts and/or polyethylene glycol; for tablets also c) binders, e.g. magnesium aluminum silicate, starch paste, gelatin, tragacanth, methylcellulose, sodium carboxymethylcellulose and/or polyvinylpyrrolidone; if desired, d) disintegrants, e.g. starches, agar, alginic acid or its sodium salt, or effervescent mixtures; and/or e) absorbents, colourants, flavours and sweeteners. Injectable compositions are preferably aqueous isotonic solutions or suspensions, and suppositories are advantageously prepared from fatty emulsions or suspensions. Said compositions may be sterilized and/or contain adjuvants, such as preserving, stabilizing, wetting or emulsifying agents, solution promoters, salts for regulating the osmotic pressure and/or buffers. In addition, the compositions may also contain other therapeutically valuable substances. Said compositions are prepared according to conventional mixing, granulating or coating methods, respectively, and contain about 0.1 to 75 %, preferably about 1 to 50 %, of the active ingredient.

Suitable formulations for transdermal application include an effective amount of a compound of the invention with carrier. Advantageous carriers include absorbable pharmacologically acceptable solvents to assist passage through the skin of the host. Characteristically, transdermal devices are in the form of a bandage comprising a backing member, a reservoir containing the compound, optionally with carriers, optionally a rate controlling barrier to deliver the compound to the skin of the host at a controlled and predetermined rate over a prolonged period of time, and means tans to secure the device to the skin.

The present invention also relates to the use of compounds of the invention having GABA_B-antagonistic properties and pharmaceutical compositions comprising said compounds for the treatment in mammals of disorders responsive to selective GABA_B-receptor blocking, particularly cognitive and memory disorders, and also of depressions and anxieties.

One aspect relates advantageously to the method of treatment of nootropic disorders in mammals, using an effective amount of a compound of the invention, preferably in the form of above-cited pharmaceutical compositions.

The dosage of active compound administered is dependent on the species of warm-blooded animal (mammal), the body weight, age and individual condition, and on the form of administration.

A unit dosage for a mammal of about 50 to 70 kg may contain between about 10 and 500 mg of the active ingredient.

The following examples are intended to illustrate the invention and are not to be construed as being limitations thereon. Temperatures are given in degrees Centigrade. If not mentioned otherwise, all evaporation are performed under reduced pressure, preferably between about 2 and 13 kPa. The structure of final products, intermediates and starting materials is confirmed by analytical methods, e.g. microanalysis and spectroscopic characteristics (e.g. MS, IR, NMR). The compounds of formula I are hereinafter referred to as 3-amino-1-R¹-2-R²-3-R³-propyl(R)phosphinic acids.

Example 1:

To a solution of 1.0 g of ethyl 3-amino-2-(p-chlorophenyl)-propyl(diethoxymethyl)phosphinate in 5 ml of methanol are added 2.5 ml of a 2 normal sodium hydroxide solution and the mixture is heated to a temperature of 80° for a period of 5 hours. After this time, the reaction is concentrated under reduced pressure, and the oily residue is passed down an Ion Exchange Resin (DOWEX® 50W-X8 H⁺) using de-ionised water as eluant. Ninhydrin-positive fractions are combined and evaporated to give 3-amino-2-(4-chlorophenyl)-propyl(diethoxymethyl)phosphinic acid, m.p. 175-185 (dec.), ³¹P-NMR : δ = +31.6 ppm (D₂O).

Example 2:

0.5 g of ethyl 3-amino-2-hydroxy-propyl(diethoxymethyl)phosphinate is dissolved in 5 ml of ethanol and this solution is added to a solution of 0.14 g of sodium hydroxide in 2 ml of water. This mixture is then heated to 60° for a period of 3 hours, cooled to room temperature and the solvent evaporated under reduced pressure. The oily residue is passed down an Ion Exchange Resin (DOWEX® 50W-X8 H⁺) using de-ionised water as eluant. Ninhydrin-positive fractions are combined and evaporated to give 3-amino-2-hydroxy-propyl(diethoxymethyl)phosphinic acid, m.p. 214-215° (dec.), ³¹P-NMR : δ = +30.9 ppm (D₂O).

The starting material may be prepared as follows:

To a solution of 25.0 g of ethyl (trimethylsilyl)diethoxymethylphosphonite in 200 ml of dry tetrahydrofuran is added 19.2 g of 2,3-epoxypropylphthalimide under an atmosphere of nitrogen. To this stirred mixture is added a catalytic amount of dry zinc chloride and the mixture is then refluxed for a period of 2 hours. After cooling, the solvent is evaporated under reduced pressure, the residue dissolved in 100 ml of chloroform, and stirred vigorously with 50 ml of water for a period of 0.5 hours. The organic layer is separated, dried over magnesium sulfate and the solvent is removed under reduced pressure. The residue is heated to 100° at 6 Pa of pressure for a period of 1 hour to leave as an oily residue ethyl 2-hydroxy-3-phthalimido-propyl(diethoxymethyl)phosphinate, ³¹P-NMR : δ = +42.0 and +41.6 ppm (CDCl₃).

To a solution of 1.0 g of ethyl 2-hydroxy-3-phthalimido-propyl(diethoxymethyl)phosphinate in 23 ml of isopropanol is added 4 ml of water. To this mixture is added 0.47 g of sodium borohydride and this is stirred for a period of 24 hours at room temperature. After this time 2.6 ml of glacial acetic acid are carefully added and the reaction heated to 80° for a period of 2 hours. After this time, the reaction is cooled to room temperature, the solvent evaporated under reduced pressure and the residue passed down a silica column using a mixture

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of one part ethyl acetate to one part ethanol as eluant. Ethyl 3-amino-2-hydroxy-propyl(diethoxymethyl)phosphinate is obtained as colourless oil, ${}^{31}\text{P} = +45.8$ and $+45.2$ ppm (CDCl_3).

Example 3:

5 A solution of 6.7 g of 3-(benzyloxycarbonylamino)propyl(n-butyl)phosphinic acid in 125 ml of 36 % hydrochloric acid is heated at reflux for 1.5 hour. The mixture is evaporated to an oil and the oil is co-evaporated with water (2×50 ml) to give a white solid. This solid is then dissolved in 50 ml of dry methanol, 1-3 ml of propylene oxide is added and the solution is stirred at room temperature. The precipitated product is collected by filtration and dried to give 3-aminopropyl(n-butyl)phosphinic acid, m.p. $231\text{-}234^\circ$ (dec.).

10 ${}^{31}\text{P-NMR} : \delta = +44.6$ ppm (D_2O).

The starting material may be prepared as follows:

15 A solution of 5.0 g of 3-aminopropylphosphinic acid in 200 ml of water is cooled to 5° , and the pH adjusted to 9.5 with 2 molar sodium hydroxide solution. To this mixture is added 6.8 g of benzyl chloroformate whilst maintaining the pH and temperature. After the addition is complete the mixture is stirred for 3 hours at pH 9.5 at room temperature and left to stand overnight. The mixture is then extracted with 100 ml of ether and the aqueous layer stirred at 5° with an equal volume of chloroform. The mixture is acidified to pH 2, the chloroform layer separated, dried over magnesium sulfate and the solvent evaporated under reduced pressure. The oily product is triturated with ether to give a white solid, 3-(N-benzyloxycarbonylamino)propylphosphinic acid, m.p. $53\text{-}55^\circ$, ${}^{31}\text{P-NMR} : \delta +36.6$ ppm (CDCl_3).

20 To a solution of 3.0 g of 3-(N-benzyloxycarbonylamino)propylphosphinic acid in 50 ml of dry tetrahydrofuran is added 2.3 g of triethylamine. This mixture is stirred under an atmosphere of nitrogen for a period of 0.5 hours, and then 2.5 g of trimethylchlorosilane is added. This solution is stirred for a period of 1 hour during which time a precipitate forms. After this time, 7.6 g of 1-bromobutane is added and the reaction is refluxed for a period of 24 hours. The mixture is then allowed to cool to room temperature, 50 ml of water is added and the whole stirred for 1 hour. The mixture is extracted with 200 ml of chloroform, the organic layer dried over magnesium sulfate and the solvent evaporated under reduced pressure. The oily product is triturated with ether to give a white solid, being 3-(N-benzyloxycarbonylamino)propyl(n-butyl)phosphinic acid, m.p. $116\text{-}118^\circ$, ${}^{31}\text{P} = +58.6$ ppm (CDCl_3).

30 **Example 4:**

A solution of 3.3 g of lithium hydroxide monohydrate in 40 ml of water is added to a solution of 20 g of ethyl 3-aminopropyl(diethoxymethyl)phosphinate in 75 ml of ethanol. The mixture is stirred and approximately 25 ml of further water is added to obtain a clear solution. The solution is stirred at room temperature until the reaction is complete after approximately 48 hours. This can be monitored by ${}^{31}\text{P-NMR}$. Then the solution is evaporated to give a cloudy oil, to which are added 50 ml of ethanol. The insoluble inorganic solid is removed by filtration and the filtrate evaporated. The residual oily product which contains a little solid is triturated with acetone and the resulting solid filtered off (${}^{31}\text{P NMR}: \delta = 33.98$ ppm; D_2O).

35 The filtrate from this is evaporated and again triturated with a little acetone to yield a second crop of product. Both crops are combined and dissolved in water. The solution is concentrated and extracted with chloroform to remove traces of starting material, then treated with charcoal. The solution is filtered to remove charcoal and reduced to a small volume. This crude product is then subjected to ion exchange chromatography (DOWEX[®] 50W-X8 H⁺ form) using de-ionised water as eluent. Fractions of 150 ml are collected. Fraction 44 and following fractions contain the 3-aminopropyl(diethoxymethyl)phosphinic acid, which is obtained in pure form after evaporation, m.p. $209\text{-}210^\circ$ (dec.).

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Example 5:

To a solution of 8.0 g of isopropyl 3-aminopropyl(t-butyl) phosphinate in 80 ml of chloroform are added 11.7 ml of trimethylsilyl bromide. The reaction mixture is stirred at 50° for 4 hours and then at room temperature overnight. Removal of chloroform and excess of trimethylsilyl bromide under reduced pressure gives an oil which is taken up in ethanol. Propylene oxide is added and the white solid is filtered off and dried over phosphorous pentoxide to yield 3-aminopropyl(t-butyl)phosphinic acid $\times 0.15 \text{ H}_2\text{O}$, m.p. $253\text{-}255^\circ$.

The starting material is prepared as follows:

55 A mixture of 24.7 g of isopropanol and 17.2 g of triethylamine in 35 ml of diethylether is added drop by drop to 30 g of t-butyl dichlorophosphine in 100 ml diethylether. The temperature is kept between 5 to 10° . The solid is filtered off and the filtrate evaporated. The crude oil is purified by distillation to yield t-butylphosphonous acid-isopropylester as an oil, b.p. $82^\circ / 2 \text{ kPa}$, $n_D^{20} = 1.4222$.

60 To 15.7 g of t-butylphosphonous acid-isopropylester in 6.3 ml of acrylonitrile are added 21 ml of sodium isopropylate (0.25 molar). After the exothermic reaction (the temp. rises to 100°) the suspension is filtered, the filtrate evaporated and the residue distilled to yield isopropyl 2-cyanoethyl(t-butyl)phosphinate as an oil, b.p. $121^\circ / 8 \text{ Pa}$, $n_D^{20} = 1.4480$.

A mixture of 11.0 g of isopropyl 2-cyanoethyl(t-butyl)phosphinate, 17.0 g of ammonia and 1.7 g of Raney-Nickel in 110 ml of ethanol is hydrogenated during 5 hours. The catalyst is filtered off and the solvent removed by evaporation. The crude oil is purified by Kugelrohr-distillation to yield isopropyl 3-aminopropyl(t-butyl)phosphinate as an oil, b.p. $155^\circ / 1 \text{ Pa}$, $n_D^{20} = 1.4600$.

Example 6:

7.0 g of isopropyl 3-aminopropyl(n-propyl)phosphinate and 40 ml of 20 % hydrochloric acid are stirred at reflux temperature overnight. The reaction mixture is evaporated to dryness, taken up in methanol and treated with propylene oxide. The white solid is filtered off and dried over phosphorous pentoxide to yield 3-aminopropyl(n-propyl)phosphinic acid x 0.1 H₂O as white crystals, m.p. 210-213°.

3-Aminopropyl(n-propyl)phosphinic acid can also be prepared from the same starting material by silylation with trimethylsilyl bromide and subsequent treatment with propylene oxide in ethanol, m.p. 213-215°.

The starting materials isopropyl 3-aminopropyl(n-propyl)phosphinate, b.p. 155°/6 Pa, n_D²⁰ = 1.4571; isopropyl 2-cyanoethyl(n-propyl)phosphinate, b.p. 132°/40 Pa, n_D²⁰ = 1.4470; and n-propylphosphorous acid-isopropylester, b.p. 93°/2.8 kPa; n_D²⁰ = 1.4241 are prepared in a similar way as described in the preceding example starting from n-propyl dichlorophosphine.

Example 7:

A mixture of 7.73 g of isopropyl 3-aminopropyl(ethyl)phosphinate and 40 ml of 20 % hydrochloric acid is refluxed with stirring for 14 hours. The clear solution is evaporated to dryness and the residue is recrystallized from methanol/propyleneoxide to give 3-aminopropyl(ethyl)phosphinic acid as a white solid, m.p. 233-239°; ¹H-NMR (D₂O): 0.4-1.8 (m, 9H, PCH₂CH₂ and PCH₂CH₃); 2.7 (t, 2H, NCH₂); 4.55 (s, 3H, OH, NH₂).

The starting materials are prepared as follows:

To a solution of 262 g of ethyl dichlorophosphine in 1200 ml of diethylether is added with stirring and cooling with ice at 5-10° a solution of 370 ml of isopropanol and 280 ml of triethylamine in 400 ml of diethylether. The reaction is exothermic. After stirring for 12 hours at 20° the white precipitate is filtered off and the filtrate is fractionally distilled. There is obtained ethylphosphorous acid-isopropylester as a colorless liquid, b.p. 80-85°/26 kPa.

To 34 g of ethylphosphorous acid-isopropylester and 16.45 ml of acrylonitrile is added with stirring 40 ml of isopropanol containing 0.25 mol of sodium isopropylate. The reaction is exothermic. After 1 hour stirring at 20° the mixture is fractionated. There is obtained isopropyl 2-cyanoethyl(ethyl)phosphinate as a colorless oil, b.p. 102-104°/10 Pa.

To 34.1 g of isopropyl 2-cyanoethyl(ethyl)phosphinate in 500 ml of isopropanol are added 60 ml of liquid ammonia and 6.8 g of Raney-Nickel. The mixture is heated to 80° and treated with hydrogen at 100 bar. After 1 1/2 hours hydrogen uptake stops. The reaction mixture is filtered and the filtrate distilled to give isopropyl 3-aminopropyl(ethyl)phosphinate as a colorless oil, b.p. 75°/13 Pa.

Example 8:

A mixture of 1.5 g of 3-aminopropyl(phenyl)phosphinic acid in 10 ml of water and 7.9 ml of 1N hydrochloric acid is treated with hydrogen at 25° in the presence of 0.2 g of Nischimura-catalyst (Rh/PtO₂). After 1.2 hours hydrogen up-take stops. The reaction mixture is filtered and the filtrate evaporated to dryness. The residue is recrystallized from methanol/propyleneoxide to give 1.2 g of 3-aminopropyl(cyclohexyl)phosphinic acid x 0.4 mol hydrochloric acid as a white solid, m.p. 202-203°.

The starting materials are prepared as follows:

To a solution of 270 ml of phenyl dichlorophosphine in 1000 ml of diethylether is added with stirring and cooling with ice a solution of 280 ml of ethanol and 280 ml of triethylamine in 500 ml of diethylether. After stirring for 14 hours at 20° the precipitate is filtered off and the filtrate is fractionally distilled. There is obtained phenylphosphorous acid-ethylester as a colorless liquid, b.p. 83-85°/6 Pa.

To 42.45 g of phenylphosphorous acid-ethylester and 16.45 ml of acrylonitrile are added with stirring 5 ml of sodium ethylate (1 molar). The reaction is exothermic. After 1 hour stirring at 20° the mixture is fractionally distilled. There is obtained ethyl 2-cyanoethyl(phenyl)phosphinate as a colorless oil, b.p. 134-136°/7 Pa.

To 22.72 g of ethyl 2-cyanoethyl(phenyl)phosphinate in 400 ml of ethanol are added 34 g of liquid ammonia and 4.5 g of Raney-Nickel. The mixture is heated to 80° and treated with hydrogen at 100 bar. After 30 minutes hydrogen up-take stops. The reaction mixture is filtered and the filtrate distilled to give ethyl 3-aminopropyl(phenyl)phosphinate as a colorless oil, b.p. 110°/13 Pa.

A mixture of 6.83 g of ethyl 3-aminopropyl(phenyl)phosphinate and 30 ml of 20 % hydrochloric acid is refluxed with stirring for 4 hours. The clear solution is evaporated to dryness and the residue is recrystallized from methanol/propyleneoxide to give 3-aminopropyl(phenyl)phosphinic acid as a white solid, m.p. 298-300°.

Example 9:

A mixture of 14.76 g (0.12 mol) of 3-aminopropylphosphorous acid and 96.72 g (0.6 mol) of hexamethyldisilazane is refluxed under an atmosphere of argon with stirring for 16 hours to give a solution. To this solution are added at reflux 60 ml of diethyleneglycol dimethylether and the solution is refluxed for additional 2 hours.

The reaction is cooled to 120° and 38.75 g (0.3 mol) of N-ethyl-diisopropyl-amine are added within 20 minutes followed by addition of 54.06 g (0.3 mol) of isobutyl iodide over a period of 20 minutes. The reaction mixture is heated with stirring for 22 hours. After cooling to 10°, the white precipitate is filtered off and the filtrate is evaporated under reduced pressure. The clear solution is cooled, diluted with dichloromethane (300 ml) and extracted three times with 2N hydrochloric acid (3 x 100 ml). The combined hydrochloric acid-extracts are evaporated in vacuo to dryness, and re-evaporated twice with water (2 x 100 ml) to give a white solid, which is

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suspended in 600 ml of acetone and stirred for 1 hour at 20°. 3-Aminopropyl(isobutyl)phosphinic acid hydrochloride (25.3 g), m.p. 149° = 155°, is isolated by filtration.

After recrystallisation from n-propanol/acetone (200/100 ml) pure 3-aminopropyl(isobutyl)phosphinic acid hydrochloride of m.p. 154-156°, is obtained. 15.4 g of 3-aminopropyl(isobutyl)phosphinic acid hydrochloride are dissolved in 75 ml of methanol and 300 ml of propylenoxide are added with stirring. After standing overnight at 4°, a white solid precipitates.

The precipitate is collected by filtration and recrystallized from n-propanol to give pure 3-aminopropyl(isobutyl)phosphinic acid, m.p. 250°-253° (dec.).

10 Example 10:

In a manner analogous to that described in Example 9, 3-aminopropyl(n-hexyl)phosphinic acid, m.p. 242°-246°, hydrochloride: m.p. 196-198°, is obtained with n-bromohexane at 130°, 22 hours.

Example 11:

15 In a manner analogous to that described in Example 9, 3-aminopropyl(allyl)phosphinic acid, m.p. 230°-234° (dec.), hydrochloride: m.p. 140-142°, is obtained by reaction with allylbromide at 60°, 16 hours.

Example 12:

20 In a manner analogous to that described in Example 9, -aminopropyl(n-pentyl)phosphinic acid m.p. 232°-236°, hydrochloride: m.p. 192-194°, is obtained by reaction with n-bromopentane at 120°, 16 hours.

Example 13:

25 In a manner analogous to that described in Example 9, 3-aminopropyl(n-heptyl)phosphinic acid, m.p. 232°-236° (dec), hydrochloride: m.p. 190-192°, is obtained by reaction with n-bromoheptane at 120°, 16 hours.

Example 14:

30 In a manner analogous to that described in Example 9, 3-aminopropyl(but-3-enyl)phosphinic acid, m.p. 215°-220°, hydrochloride: m.p. 170-172°, is obtained by reaction with 4-bromo-1-butene at 95°, 16 hours.

Example 15:

35 In a manner analogous to that described in Example 9, 3-aminopropyl(n-decyl)phosphinic acid, m.p. 225°-230°, hydrochloride m.p. 185-190°, is obtained by reaction with n-bromodecane at 120°, 20 hours.

Example 16:

40 In a manner analogous to that described in Example 9, 3-aminopropyl(isopentyl)phosphinic acid, m.p. 238°-240° (dec.), hydrochloride: m.p. 159-161°, is obtained by reaction with 1-bromo-3-methylbutane at 120°, 22 hours.

Example 17:

45 In a manner analogous to that described in Example 9, 3-aminopropyl(cyclopropylmethyl)phosphinic acid x 0,16H₂O, m.p. 235°-238° (dec.), hydrochloride: m.p. 144-146°, is obtained by reaction with bromomethyl-cyclopropane at 100°, for 22 hours.

Example 18:

50 In a manner analogous to that described in Example 9, (1-methyl-3-aminopropyl)(n-butyl)phosphinic acid x 0,2H₂O, m.p. 212°-215°, hydrochloride: m.p. 137-139°, is obtained by reaction of 1-methyl-2-amino-propylphosphorous acid with n-butylbromide at 100°, 48 hours.

Example 19:

55 In a manner analogous to that described in Example 9, 3-aminopropyl(pent-3-yanyl)phosphinic acid x 0,2H₂O, m.p. 220°-224° (dec.), hydrochloride: m.p. 174-176°, is obtained by reaction with 5-iodopent-2-yne at 60°, 16 hours.

Example 20:

60 In a manner analogous to that described in Example 9, 3-aminopropyl(but-3-yanyl)phosphinic acid, m.p. 214°-218°, hydrochloride: m.p. 148-150°, is obtained by reaction with 4-iodobut-1-yne at 90°, 16 hours.

Example 21:

65 In a manner analogous to that described in Example 9, 3-aminopropyl(2-thoxyethyl)phosphinic acid x 0,14H₂O m.p. 202°-208°, is obtained by reaction with (2-bromoethoxy)ethane at 100°, 16 hours.

Example 22:

70 In a manner analogous to that described in Example 9, 3-aminopropyl(2-methylbutyl)-phosphinic acid x 0,1H₂O, m.p. 248°-254°, is obtained by reaction with 2-methylbutyl iodide at 100°, 16 hours.

2-Methylbutyliodide may be prepared in the following manner.

17.63 g (0.20 mol) of 2-methyl-butanol is added slowly during 20 minutes with stirring to a mixture of 43.3 g (0.227 mol) of toluene-p-sulphonylchloride in 20 ml of dry pyridine, keeping the temperature below 25° by external cooling. After stirring for 2 hours at 20°, the mixture is poured into ice-water and extracted with ether. The ether layer is washed subsequently with 2 N sulphic acid, water and saturated sodium hydrogencarbonate solution. After drying over sodium sulphate, filtration and evaporation in vacuo 2-methylbutyl toluene-p-sulphonate are obtained as a yellow oil.

45.99 g (0.189 mol) of 2-methylbutyl toluene-p-sulphonate are dissolved in 290 ml of acetone, 34.7 g (0.23 mol) of sodium-iodide is added at 20° and the mixture is stirred for 2 hours under reflux. After cooling to 0° the separated sodium toluene-p-sulphonate is removed by filtration, and the solvent is evaporated through a 15 cm Vigreux-column at atmospheric pressure.

The crude product is dissolved in ether and washed with 10 % sodium thiosulphate solution, dried over sodium sulphate and filtered off. Evaporation of the solvent through a 15 cm Vigreux column, followed by fractionational distillation gives 2-methylbutyliodide; b.p. 93°/200 mbar.

Example 23:

In a manner analogous to that described in Example 9, 3-aminopropyl-(3-ethoxypropyl)-phosphinic acid x 0.1H₂O, m.p. 210°-218°; hydrochloride: m.p. 161-165°, is obtained by reaction with 2-ethoxypropyl iodide at 130°, 16 hours.

3-Ethoxypropyl iodide may be prepared in the following manner.

20.8 g (0.20 mol) of 2-ethoxypropanol are added slowly during 20 minutes with stirring to a mixture of 43.3 g (0.227 mol) of toluene-p-sulphonylchloride and 20 ml of dry pyridine. The temperature of the reaction mixture is kept at 20° with external cooling. After stirring for 2 hours at 20°, the mixture is poured into ice-water and extracted with ether. The ether layer is washed with 2N sulphuric acid, with water and with saturated sodium hydrogencarbonate solution. After drying over sodium sulphate, filtration and evaporation in vacuo, 2-ethoxypropyl toluene-p-sulphonate is obtained as a yellow oil.

A solution of 51.5 g (0.199 mol) of 2-ethoxypropyl toluene-p-sulphonate and 36.5 g (0.243 mol) of sodium iodide in 250 ml of acetone is stirred under reflux for 2 hours. After cooling to 10°, the separated sodium toluene-p-sulphonate is removed by filtration, and the solvent is evaporated through a 15 cm Vigreux-column at atmospheric pressure.

The crude product is dissolved in ether and washed with a 10 % (b.w.) solution of sodium thiosulphate. Drying over sodium sulphate, filtration and evaporation of the solvent through a 15 cm Vigreux column, followed by fractional distillation yields 3-ethoxypropyl iodide, b.p. 97°/40 mbar.

Example 24:

In a manner analogous to that described in Example 9, 3-aminopropyl(3-methoxypropyl)phosphinic acid x 0.25H₂O; m.p. 197°-203°, hydrochloride: m.p. 146-148°, is obtained by reaction with 2-methoxypropyl iodide at 115°, 40 hours.

Example 25:

In a manner analogous to that described in Example 9, 3-aminopropyl(but-2-ynyl)phosphinic acid x 1,2H₂O; m.p. 110°-115°, hydrochloride: m.p. 154-158°, is obtained by reaction with 1-bromo-2-butyne at 90° for 16 hours.

Example 26:

In a manner analogous to that described in Example 9, 3-aminopropyl[2-(2-ethoxyethoxy)ethyl]phosphinic acid x 0.16H₂O m.p. 215°-225°, is obtained by reaction with [2-(2-ethoxyethoxy)ethyl]iodide.

Example 27:

In a manner analogous to that described in Example 9, 3-aminopropyl(4,4,4-trifluorobutyl)phosphinic acid, m.p. 237-241° (decomp.), hydrochloride: m.p. 144°-146°, is obtained by reaction with 4,4,4-trifluorobutyl iodide at 95°, 16 hours.

Example 28:

In a manner analogous to that described in Example 9, 3-aminopropyl(2-methylthioethyl)phosphinic acid is obtained by reaction with 1-chloro-2-methylthio-ethane at 100°, 16 hours.

Example 29:

In a manner analogous to that described in Example 9, 3-aminopropyl(methylthiomethyl)phosphinic acid is obtained by reaction with methylthiomethyl chloride at 75°, 16 hours.

Example 30:

In a manner analogous to that described in Example 9, 3-aminopropyl(2-phenylethyl)phosphinic acid, m.p. 265°-270° is obtained by reaction with 2-phenylethylbromide at 120°, 16 hours.

Example 31:

In a manner analogous to that described in Example 9, 3-aminopropyl(2-methylallyl)phosphinic acid, m.p. 140°-143°, is obtained by reaction with methallyl chloride at 63°, 24 hours.

5 Example 32:

A solution of 2.4 g of 3-benzyloxycarbonylaminopropyl-(dodecyl)phosphinic acid in 50 ml of 36% hydrochloric acid is refluxed for 3 hours. During this time, a white precipitate is formed. After cooling to room temperature the acid is removed by co-evaporation with 6 x 50 ml of water on a rotary evaporator. The crude product is then dissolved in 50 ml of ethanol and stirred with 5 ml of propylene oxide. Filtration and 10 drying gives 3-aminopropyl-(dodecyl)phosphinic acid as a white solid m.p. 175-7°. $^{31}\text{P-NMR}$ = 43.0 ppm (NaOD).

The starting material can be prepared as follows:

A solution of 1.30 g of dodecene in 6 ml of dry toluene is heated to 80° under an atmosphere of argon. To this 15 solution a suspension of 2.0 g of 3-benzyloxycarbonylaminopropylphosphorous acid in 30 ml of dry toluene containing 0.6 g of t-butylcyclohexylperdicarbonate is added within 15 minutes. The reaction mixture is then stirred at 80° for 2 hours. An additional amount of 0.6 g of the radical initiator is added and stirring at 80° is continued for 2 hours. Then, the reaction mixture is cooled to room temperature and the solvent is removed by means of a rotary evaporator. The residue is triturated with petroleum ether (60-80°), filtered and dried to give 3-benzyloxycarbonylaminopropyl(dodecyl)phosphinic acid as a white solid, m.p. 115-6°; $^{31}\text{P-NMR}$; 20 δ = + 58.7 ppm (CDCl_3).

Example 33:

To a solution of 5.7 g (0.0224 mol) of isopropyl 3-aminopropyl(benzyl)phosphinate in 50 ml of chloroform 25 9.91 ml (0.0922 mol) of trimethylsilyl bromide are added raising the temperature to 44°. The reaction mixture is stirred at 50° for 4 hours and then at room temperature overnight. Removal of the chloroform and excess trimethylsilyl bromide under reduced pressure yields an oil which is taken up in isopropanol and 20 ml of propylene oxide. After stirring for 10 minutes, a white solid precipitates. The solid is filtered off and dried over phosphorous pentoxide yielding 3-aminopropyl(benzyl)phosphinic acid, m.p. 278-280°.

The starting material can be prepared from benzyl-dichloro-phosphine via benzylphosphonous acid 30 isopropylester, b.p. 113° (1 mbar), isopropyl 2-cyanoethyl(benzyl)phosphinate, m.p. 69-72°, and isopropyl 3-aminopropyl(benzyl)phosphinate, b.p. 113° (1 mbar).

Example 34:

A suspension of 1.23 g (10 mmol) of 3-aminopropylphosphorous acid in 10.4 ml (50 mmol) of hexamethyldisilazane is heated to reflux under argon for 24 hours. 5 ml of diethylene glycol dimethyl ether are 35 added to the clear solution obtained and the mixture is heated for additional 2 hours and then cooled to 0°. 8.5 ml (50 mmol) of N-ethyl-N,N-diisopropyl-amine are added, followed by slow addition of 3.8 ml (50 mmol) of propargyl bromide over a period of 40 minutes. The mixture is stirred for 1 hour at 0° and 4 hours at room 40 temperature, filtered and evaporated under high vacuum. The residue is dissolved in 10 ml of dichloromethane and extracted with 3 x 10 ml of 1N hydrochloric acid solution. The water layer is evaporated under high vacuum and the residue obtained dissolved in 4 ml of methanol at 0°. 20 ml of propylene oxide are added during a period of 1 hour, after which time a crude product precipitates. Chromatography (silicagel Merck 230-400 ASTM, methanol) followed by recrystallization (methanol/ether) yields 3-aminopropyl-(propargyl)-phosphinic acid, m.p. 172-173°.

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Example 35:

To a solution of 0.90 g (4.0 mmol) of 3-aminopropyl(diethoxymethyl)phosphinic acid in 10 ml of glacial acetic acid at 0° there are added 0.38 ml (4.4 mmol) of ethane-1,2-dithiol, followed by addition of 2 ml of concentrated hydrochloric acid over a period of 5 min. The mixture is allowed to warm to room temperature and is then 50 stirred for 18 hours. After removal of acetic and hydrochloric acids under high vacuum, the residue is chromatographed (Opti-Up® C₁₂ 50 %, water) and recrystallized from methanol to yield 3-aminopropyl(1,3-dithiolan-2-yl)phosphinic acid, m.p. 272-274°.

Example 36:

To 590 mg (2.20 mmol) of lithium hydroxide monohydrate in 1.1 ml of water a solution of 2 mmol of ethyl 55 3-aminobutyl(diethoxymethyl)phosphinate in 2.1 ml of ethanol, and then 1 ml of water are added. The mixture is stirred 48 hours at room temperature and evaporated in vacuo. 3 ml of water are added to dissolve the precipitate formed. Then 85 mg of 84 % (b.w.) phosphoric acid are added slowly and the suspension is stirred for 18 hours at room temperature. After filtration of the precipitate through celite, evaporation to dryness, 60 chromatography (Opti-Up® C₁₂ 50 %, H₂O) and recrystallisation from ethanol, 3-aminobutyl(diethoxymethyl)phosphinic acid, m.p. 225-228°, is obtained.

The starting material may be obtained as follows:

A mixture of 2.7 g of ethyl trimethylsilyldiethoxymethylphosphonite and 0.7 g of methyl vinyl ketone is warmed to 50° for 1 hour under an atmosphere of nitrogen. Then 10 ml of water are added and the mixture is stirred for additional 30 minutes. The residue is extracted thrice with 50 ml of chloroform, the organic phases are 65

combined, dried over magnesium sulphate, filtered and evaporated to dryness. The residue is then distilled to yield ethyl 3-oxobutyl(diethoxymethyl)phosphinate, b.p. 130-5° (13.6 mbar).

A mixture of 1.0 g of ethyl 3-oxobutyl(diethoxymethyl)phosphinate 2.85 g of ammonium acetate and 0.16 g of sodium cyanoborohydride in 20 ml of methanol is stirred for 2.5 hours. After standing overnight, the pH is adjusted to pH 5.6 with 2N hydrochloric acid. The mixture is then evaporated to dryness. 20 ml of water are added and the mixture is washed 3 times with 20 ml of diethyl ether. The aqueous layer is adjusted to pH 12 with potassium hydroxide and extracted 4 times with 25 ml of chloroform. The organic layers are combined, dried, filtered and evaporated to dryness yielding ethyl 3-aminobutyl(diethoxymethyl)phosphinate, ^{31}P -NMR spectrum: $\delta = +46.0$ ppm (CDCl_3). 10

Example 37:

In an analogous manner, by saponification with lithium hydroxide in aqueous ethanol 3-amino-1-(p-chlorophenyl)-propyl(diethoxymethyl)phosphinic acid is obtained as a yellow oil; ^1H -NMR (CDCl_3): δ 7.2-7.4 (m, 4), 4.1 (d, 1, $J = 6.5$ Hz), 3.7 (m, 2), 3.6 (m, 2), 3.3 (t, 1, $J = 7.5$ Hz), 3.1 (m, 2), 3.0 (m, 4), 2.7 (m, 2), 2.2 (broad, 2), 1.2 (m, 6). 15

The starting material, ethyl 3-amino-1-(p-chlorophenyl)propyl(diethoxymethyl)phosphinate, may be obtained as follows:

A mixture of 25.8 g of ethyl diethoxymethylphosphinate, 18.0 g of 4-chlorcinnamoyl nitrile and 100 ml of ethanol is added dropwise at 0 to 5° to a stirred solution of 1.2 g of sodium hydride (50 % suspension in mineral oil) in 30 ml of ethanol. Then the ethanol is evaporated, the residue is dissolved in 100 ml of chloroform and washed twice with 25 ml of water, the organic phase is dried over magnesium sulfate, filtered and evaporated to yield 20 g of ethyl 1-(p-chlorophenyl)-2-cyano-ethyl(diethoxymethyl)phosphinate as an oil, ^{31}P -NMR: $\delta +37.8$ and +37.9 ppm (CDCl_3). 20

A solution of 20.0 g of ethyl 1-(p-chlorophenyl)-2-cyano-ethyl(diethoxymethyl)phosphinate in 131 g of a 8 % (b.w.) ethanolic solution of ammonium is stirred with 8.5 ml of Raney Nickel in 85 ml of ethanol, and hydrogenated until hydrogen uptake ceased. Filtration and evaporation then gives ethyl 3-amino-1-(p-chlorophenyl)propyl(diethoxymethyl)phosphinate as an oil. 25

Example 38:

To a stirred solution of 0.05 g of lithium hydroxide monohydrate in 7.7 ml of water, is added a solution of 4.37 g of ethyl 3-aminopropyl(di-n-propyloxymethyl)phosphinate in 16.2 ml of ethanol. A slight exothermic reaction ensues and the reaction mixture becomes cloudy. A further 2 ml of water are added and the clear solution is stirred at room temperature for 5 days. After this time the mixture is concentrated in vacuo at 55° and the residue redissolved in water and extracted with 3 x 10 ml of dichloromethane. The aqueous layer is again evaporated to dryness and the residue dissolved in 20 ml of water and treated with 0.51 ml of 85 % phosphoric acid. After stirring overnight, the solid is removed by filtration. Evaporation of the filtrate and crystallisation of the residue from ethanol/ether affords 3-aminopropyl(di-n-propyloxymethyl)phosphinic acid, m.p. 223-225°, as a white solid. 30

The starting material may be prepared as follows:

A mixture of 6.6 g of hypophosphorous acid (95 % solution in water) and 86 g of tri-n-propyl orthoformate is treated with 0.77 ml of trifluoroacetic acid. The two-phase mixture is stirred at room temperature for 48-72 hours until the reaction is complete. This can be monitored by ^{31}P -NMR or thin layer chromatography. The reaction mixture is diluted with 200 ml of dichloromethane and washed twice with 150 ml of a saturate aqueous solution of sodium bicarbonate. After drying the dichloromethane layer over anhydrous magnesium sulphate and removal of the solvent in vacuo, a colorless oil is obtained which after distillation affords di-n-propyloxymethylphosphorous acid n-propyl ester, b.p. 45°/2 x 10⁻⁴ mbar. 35

A solution of sodium ethoxide in absolute ethanol (0.48 g of sodium metal in 15 ml of absolute ethanol) is cooled to 0° under nitrogen or argon. A solution of 2.72 g of acrylonitrile and 12.2 g of di-n-propyloxymethylphosphorous acid n-propylester in 50 ml of absolute ethanol is added at such a rate that the temperature does not exceed 5°. After the addition is completed, the solution is allowed to warm to room temperature and stirred overnight. After addition of 1.22 g of glacial acetic acid, the reaction mixture is concentrated in vacuo. The residue is partitioned between ethyl acetate and water and the organic phase separated. After drying over anhydrous magnesium sulphate the solvent is evaporated in vacuo to afford an oil. Chromatography on silica-gel yields ethyl 2-cyanoethyl(di-n-propyloxymethyl)phosphinate as a colourless oil. 40

A mixture of 4.35 g of ethyl 2-cyanoethyl(di-n-propyloxymethyl)phosphinate, 10 g of ammonia and 2.3 g of Raney-Nickel in 170 ml of ethanol is hydrogenated for 10.5 hours. The catalyst is filtered off and the solvent is removed by evaporation. The crude oil is purified by distillation to yield ethyl 3-aminopropyl(di-n-propyloxymethyl)phosphinate as a colourless oil. 45

Example 39:

In a manner analogous to that scribed in Example 38, 3-aminopropyl(diisopropyloxymethyl)phosphinic acid, m.p. 175° m.p. (d.c.) can be prepared.

The starting materials: Diisopropyloxymethylphosphorous acid isopropylester, b.p. 48°, 2 x 10⁻⁴ mbar; ethyl 2-cyanoethyl(diisopropyloxymethyl)phosphinate and ethyl 3-aminopropyl(diisopropyloxymethyl)phosphinate are prepared as described in Example 38 from hypophosphorous acid and triisopropyl orthoformate. 50

Example 40:

In a manner analogous to that described in Example 38, 3-aminopropyl(di-n-butyloxymethyl)phosphinic acid, m.p. 221-224°, can be prepared.

5 The starting materials: di-n-butyloxymethylphosphorous acid n-butylester, b.p. 75°, 2.0 x 10⁻⁴ mbar; ethyl 2-cyanoethyl(di-n-butyloxymethyl)phosphinate and ethyl 3-aminopropyl(di-n-butoxymethyl)phosphinate are prepared as described in Example 38 from hypophosphorous acid and tri-n-butyl orthoformate.

Example 41:

10 To a stirred solution of 0.57 g of lithium hydroxide monohydrate in 10 ml of water is added a solution of 2.0 g of ethyl-3-aminopropyl(tetrahydrofuran-2-yl)phosphinate in 20 ml of ethanol. A slight exothermic reaction ensues and the reaction mixture becomes turbid. A further 5 ml of water is added and the then clear solution stirred for 3 days at room temperature. After this time, the reaction mixture is concentrated in vacuo at 55°. The residue is re-dissolved in water and washed with 3 x 10 ml of dichloromethane. The aqueous layer is again 15 evaporated to dryness and the residue dissolved in 10 ml of water and treated with 0.65 ml of 85 % phosphoric acid in 2 ml of water. After stirring overnight, the solid is removed by filtration. Evaporation of the filtrate and crystallisation of the residue from methanol/ether affords 3-aminopropyl(tetrahydrofuran-2-yl)phosphinic acid, m.p. 222-223° (dec.), as a white solid.

20 The starting material can be prepared either from diethoxymethyl- or diethoxyethylphosphorous acid as follows:

25 A solution of 12.7 g of diethoxymethylphosphorous acid ethyl ester and 6.95 g of 4-chlorobutanal in 10 ml of absolute ethanol is cooled to 0° under inert gas. Ethanolic sodium ethoxide (from 1.5 g of sodium metal and 20 ml of absolute ethanol) is added dropwise so that the temperature does not rise above 5°. After the addition is completed, the reaction mixture is warmed to room temperature and stirred for 20 hours. After this time a suspension results and the solvent is removed in vacuo. The residue is dissolved in dichloromethane/water and the organic layer separated and washed with a further 20 ml of water. After drying with anhydrous magnesium sulphate and removal of the solvent in vacuo O-ethyl-P-Piethoxymethyltetrahydrofuran-2-yl-phosphinate, b.p. 125°/1 x 10⁻² mbar, is obtained.

30 A suspension of 5.32 g of O-ethyl-P-diethoxymethyltetrahydrofuran-2-yl phosphinate in 50 ml of 6.0 M aqueous hydrochloric acid is heated to 100° for 16 hours. After this time the solution is evaporated to dryness in vacuo and the residue co-evaporated in vacuo with 5 x 20 ml of water followed by 5 x 20 ml of water followed by 5 x 10 ml of absolute ethanol. Drying the residue over phosphorous pentoxide in high vacuum at room temperature yields P-tetrahydrofuran-2-yl-phosphorous acid; ¹H-NMR (CDCl₃): δ 11.24 (1 H, s exchanges with D₂O), 6.97 (1 H, d, J = 557 Hz), 4.07 (1 H, a). 3.90 (2 H, t, CH₂O), 2.15 (2 H, m), 1.99 (2 H, m).

35 A solution of 2.6 g of P-tetrahydrofuran-2-yl-phosphorous acid in 20 ml of anhydrous dichloromethane is cooled to 5° under inert gas and treated with 2.03 g of triethylamine. A dichloromethane solution of 2.17 g of ethyl chloroformate is added dropwise whereupon an exothermic reaction and a gas evolution ensues. The suspension is warmed to room temperature and stirred for 3 hours. The reaction mixture is then diluted with dichloromethane and washed with water. Drying of the organic phase with anhydrous magnesium sulphate and removal of the solvent in vacuo affords P-tetrahydrofuran-2-ylphosphorous acid ethyl ester, b.p. 90°/8 x 10⁻² mbar.

40 A mixture of 0.68 g of acrylonitrile and 2.11 g of tetrahydrofuran-2-yl phosphorous acid ethyl ester in 5 ml of absolute ethanol is cooled to 0° under argon and treated, dropwise, with an ethanolic solution of sodium ethoxide (from 0.15 g of sodium metal and 15 ml of absolute ethanol) at such a rate so that the temperature does not exceed 5° (extremely exothermic). After the addition is completed the reaction mixture is stirred at room temperature for 30 minutes and 0.4 g of glacial acetic acid are added. The solvent is removed in vacuo and the residue partitioned between dichloromethane water. The organic layer is dried with anhydrous magnesium sulphate and removed in vacuo to afford ethyl 2-cyanoethyl(tetrahydrofuran-2-yl)-phosphinate; ¹H-NMR (CDCl₃): δ 4.15 (3 H, m), 3.90 (2 H, m), 2.72 (2 H, m, CH₂CN), 2.34-1.87 (6 H, m), 1.32 (3 H, m, CH₃).

50 A solution of ethyl-2-cyanoethyl(tetrahydrofuran-2-yl)phosphinate in absolute ethanol containing 10 % by weight of ammonia is hydrogenated over Raney-Nickel for 2.5 hours. The catalyst is removed by filtration and the solvent removed in vacuo to afford ethyl-3-aminopropyl(tetrahydrofuran-2-yl) phosphinate; ¹H-NMR (CDCl₃): δ 4.24 (4 H, m), 3.95 (1 H, m), 2.88 (2 H, sharpens on D₂O addition; CH₂NH₂), 2.40-1.75 (6 H, m), 1.32 (3 H, t).

55 A solution of 2.10 g of 1,1-diethoxyethylphosphorous acid ethyl ester and 1.06 g of 4-chlorobutanal in 10 ml of absolute ethanol is cooled to 0° under inert gas. Ethanolic sodium ethoxide (from 0.23 g of sodium metal and 20 ml of absolute ethanol) is added dropwise so that the temperature does not exceed 5°. After the addition is completed, the reaction mixture is warmed to room temperature and stirred for 20 hours. After this time a suspension results and the solvent is removed in vacuo. The residue is dissolved in dichloromethane/water and the organic layer separated and washed with a further 20 ml of water. After drying of the organic phase with anhydrous magnesium sulphate and evaporation in vacuo ethyl 1,1-diethoxyethyl(tetrahydrofuran-2-yl)phosphinate is obtained as a clear oil, b.p. 110°/1 x 10⁻² mbar.

60 A solution of 1 g of ethyl 1,1-diethoxyethyl(tetrahydrofuran-2-yl)phosphinate in 10 ml of dichloromethane containing 1 % (b.v.) of ethanol is treated with 0.71 g of trimethylsilylchloride. The faintly cloudy solution is stirred overnight at room temperature after which time thin layer chromatography indicates complete reaction.

Removal of the solvent in vacuo affords a colourless oil which after distillation yields P-tetrahydrofuran-2-yl-phosphorous acid ethyl ester, b.p. 90°/8 x 10⁻² mbar.

Further elaboration of P-tetrahydrofuran-2-yl-phosphorous acid ethyl ester to ethyl 2-cyanoethyl(tetrahydrofuran-2-yl)phosphinate and ethyl 3-aminopropyl(tetrahydrofuran-2-yl)phosphinate proceeds in a manner identical to that described in example 41.

Example 42:

A suspension of 2.46 g of 3-aminopropylphosphorous acid in 20 ml of hexamethyldisilazane is heated to reflux under an inert gas for 24 hours. The resulting clear solution is cooled to room temperature and 14.8 g of freshly distilled n-butyraldehyde are added. An exothermic reaction ensues, the reaction temperature, rising to approximately 60°C. The reaction mixture is stirred for 1 hour at a temperature between 10° and 60°. After cooling to room temperature, the volatile materials are removed in vacuo to yield a colourless oil. This oil is dissolved in water and stirred at room temperature for 1 hour and the aqueous layer is evaporated to dryness at 55°. A semi-solid residue is obtained which is dissolved in 50 ml of 2.0 M aqueous hydrochloric acid and washed with dichloromethane, (3 x 100 ml), and ether (1 x 100 ml). After removal of the water the white solid is co-evaporated with water (10 x 50 ml), and then with 10 x 50 ml of absolute ethanol. Crystallisation of the residue from ethanol yields 3-aminopropyl(1-hydroxybutyl)phosphinic acid hydrochloride, m.p. 154-160°. Treatment of the hydrochloride with propylene oxide/ethanol or passage through a DOWEX® 50 W x 8 (14-40 mesh) ion-exchange column gives 3-aminopropyl(1-hydroxybutyl)phosphinic acid, m.p. 187-188°, as a white solid.

Example 43:

In a manner analogous to that described in Example 42, 3-aminopropyl(1-hydroxyisobutyl)phosphinic acid hydrochloride, m.p. 105° (dec.) and 3-aminopropyl(1-hydroxyisobutyl)phosphinic acid, m.p. 122-123° are obtained by reaction with isobutyraldehyde at 40-60° for 1 hour.

Example 44:

In a manner analogous to that described in Example 42, 3-aminopropyl(1-hydroxyethyl)phosphinic acid hydrochloride, m.p. 153-154° and 3-aminopropyl(1-hydroxyethyl)phosphinic acid, m.p. 255-256° may be obtained by reaction with acetaldehyde at 0-15° for 1 hour.

Example 45:

In a manner analogous to that described in Example 42, 3-aminopropyl(1-hydroxybenzyl)phosphinic acid hydrochloride, m.p. 173-174° and 3-aminopropyl(1-hydroxybenzyl)phosphinic acid, m.p. 139-140° are obtained by reaction with freshly distilled benzaldehyde at 40-60° for 1 hour.

Example 46:

In a manner analogous to that described in Example 42, 3-aminopropyl(1-hydroxy-4,4,4-trifluoro-butyl)phosphinic acid hydrochloride, m.p. 139.5-140° and 3-aminopropyl(1-hydroxy-4,4,4-trifluorobutyl)phosphinic acid, m.p. 226-227° are obtained by reaction with 4,4,4-trifluorobutanal at 20° for 1 hour.

Example 47:

In a manner analogous to that described in Example 42, 3-aminopropyl[1-hydroxy-(Z)-2-fluoro-but-2-enyl]phosphinic acid hydrochloride, m.p. 110-112° and 3-aminopropyl(1-hydroxy-2-fluoro-(Z)-but-2-enyl)phosphinic acid, m.p. 121-122° are obtained by reaction with (Z)-2-fluorocrotonaldehyde at 0° (very exothermic) for 1 hour.

Example 48:

In a manner analogous to that described in Example 42, 3-aminopropyl(1-hydroxy-1-cyclopropylmethyl)phosphinic acid hydrochloride, m.p. 135-136° and 3-aminopropyl(1-hydroxy-1-cyclopropylmethyl)phosphinic acid, glass: δ (1H-NMR, D₂O); 2.90 (3 H, d and t, CHOH, CH₂NH₂), 1.77 (4 H, m), 0.89 (2 H, m, CH), 0.49 (2 H, m, CH₂), 0.22 (2 H, m, CH₂) are obtained by reaction with 1-formyl cyclopropane at 20° for 1 hour.

Example 49:

In a manner analogous to that described in Example 42, 3-aminopropyl[1-hydroxy-1-(1-methylthiocyclopropyl)methyl]phosphinic acid hydrochloride, m.p. 100° (dec.) and 3-aminopropyl[1-hydroxy-1-(1-methylthiocyclopropyl)methyl]phosphinic acid, m.p. 105-106° may be obtained by reaction with 1-formyl-1-methylthiocyclopropane at 40°-60° for 1 hour.

Example 50:

In a manner analogous to that described in Example 42, 3-aminopropyl(1-hydroxy-1-cyclobutylmethyl)phosphinic acid hydrochloride, m.p. 167-168° and 3-aminopropyl(1-hydroxy-1-cyclobutylmethyl)phosphinic acid, m.p. 225-226° are obtained by reaction with 1-formylcyclobutane at 40-60° for 1 hour.

Example 51:

A suspension of 2.46 g of 3-aminopropylphosphorous acid in 20 ml of hexamethyldisilazane is heated to reflux under an inert gas for 24 hours after which a clear solution results. The excess hexamethyldisilazane is removed by distillation at atmospheric pressure under a slight positive pressure of inert gas to afford a colourless oil. The oil is cooled to circa 40° and treated with 0.64 g of anhydrous zinc iodide and 25 ml of 1,2-epoxybutane. An exothermic reaction occurs and the epoxybutane refluxes. Reflux is continued for 6 hours after which time thin layer chromatography indicates the reaction to be complete. The reaction mixture is filtered and the filtrate evaporated to dryness in vacuo at 40°. The residue is dissolved in water and stirred at room temperature for 1 hour and the water removed in vacuo to give an oily solid. This is dissolved in some 2.0 M aqueous hydrochloric acid and washed with dichloromethane and ether. Removal of the water at 40° in vacuo affords a brown solid which is purified by ion-exchange chromatography on DOWEX® 50 W x 8 (14-40 mesh) to give 3-aminopropyl(-2-hydroxybutyl)phosphinic acid, m.p. 184-185°. as a white solid.

Example 52:

In a manner analogous to that described in Example 51, 3-aminopropyl[2-(R)-hydroxy-3-methylbutyl]phosphinic acid, m.p. 187-189° is obtained by reaction with (R)-(-)-1,2-epoxy-3-methylbutane at 70°.

Example 53:

A suspension of 2.46 g of 3-aminopropylphosphorous acid in 20 ml of hexamethyldisilazane is heated to reflux under an inert gas for 24 hours. The resulting clear solution is cooled to 15° and 2.0 ml of cyclobutanone are added. An exothermic reaction ensues. The reaction mixture is stirred until the temperature drops to room temperature (approximately 1 hour). Water is added and the volatile materials are removed in vacuo to yield a semi-solid. This is dissolved in 2.0 M aqueous hydrochloride acid and washed with 2 x 100 ml of dichloromethane. The aqueous layer is evaporated in vacuo to afford a solid which is passed through a DOWEX® 50 W x 8 (14-40 mesh) ion-exchange column to give 3-aminopropyl(1-hydroxycyclobutyl)phosphinic acid, m.p. 174-175° (dec.).

Example 54:

A mixture of 3.0 g of 3-aminopropyl(benzyl)phosphinic acid hydrochloride and 0.6 g of Nischimura catalyst in 30 ml of methanol is hydrogenated during 4 hours. The catalyst is filtered off and the solvent removed by evaporation. The residue is dissolved in 20 ml of methanol and 10 ml of propyleneoxide are added to the solution. Stirring for 3 hours affords a white solid which is filtered off and dried over phosphorous pentoxide to yield 3-aminopropyl(cyclohexylmethyl)phosphinic acid, m.p. 230° (dec.).

Example 55:

A solution of 1 g of 3-aminopropyl(but-3-enyl)phosphinic acid in 25 ml of water is treated with 0.1 g of 5% palladium on charcoal and hydrogenated at room temperature until hydrogen uptake ceases. The catalyst is removed by filtration of the reaction mixture through celite and the filtrate evaporated to dryness, to afford 3-aminopropyl(butyl)phosphinic acid, m.p. 231-234° (dec.) ^{31}NMR (D_2O): δ +44.6 ppm.

Example 56:

A suspension of 25.7 g of 3-(N-benzyloxycarbonylaminopropyl)phosphorous acid in 150 ml of anhydrous dichloromethane is cooled to 5° under an inert gas and 11.1 g of triethylamine is added. A slight exotherm results and all the solid dissolves. The solution is re-cooled to 0° and a solution of 11.94 g of ethyl chloroformate in 100 ml of anhydrous dichloromethane is added dropwise over 15-30 minutes, maintaining the temperature at 10°. The reaction is exothermic and gas evolution together with the formation of a white precipitate is observed. The white suspension is stirred for 1 hour at room temperature, diluted with 500 ml of dichloromethane and washed with 2 x 200 ml of water. After drying the organic phase with anhydrous magnesium sulfate and evaporation of the solvent in vacuo 3-(N-benzyloxycarbonylaminopropyl)phosphorous acid ethyl ester is obtained as a colourless viscous oil; $^1\text{H-NMR}$: δ (CDCl_3): 7.35 (5 H, m, Ph), 7.13 (1 H, d, J = 530 Hz, P-h), 5.08 (2 H, m, CH_2Ph), 4.13 (2 H, m, P-OCH₂), 3.27 (2 H, brd, sharpens on D_2O addition, CH_2NH_2), 1.82 (4 H, m, 2 x CH_2), 1.35 (3 H, t, CH_3)

A solution of 2.85 g of 3-(N-benzyloxycarbonylaminopropyl)phosphorous acid ethyl ester in 25 ml of anhydrous tetrahydrofuran is cooled to 0° under an inert gas and 2.22 g of triethylamine added followed by dropwise addition of a solution of 2.39 g of trimethylsilylchloride in 25 ml of anhydrous tetrahydrofuran over 15 minutes. A slight exotherm reaction occurs and a white precipitate is observed. The suspension is stirred at room temperature for 20 hours and filtered under inert gas. The solid is washed with a further 50 ml of anhydrous tetrahydrofuran under inert gas and the combined organic filtrate evaporated to dryness in vacuo to afford a slightly cloudy colourless oil. This oil is treated with 10-15 ml of freshly distilled n-butyraldehyde maintaining an inert atmosphere. An exothermic reaction ensues, the temperature rising circa 35°. The mixture is allowed to cool to room temperature, is diluted with 100 ml of dichloromethane and washed with water. 0.1 ml of aqueous hydrochloride acid followed by water. Drying of the solvent and removal of the dichloromethane in vacuo yields ethyl 3-(N-benzyloxycarbonylaminopropyl)(1-hydroxybutyl)phosphinate as a mixture of diastereoisomers; $^1\text{H-NMR}$: δ (CDCl_3): 7.35 (5 H, m), 5.10 (1 H, n), 4.25-3.98 (1 H, m, CHO_H), 3.28 (2 H, t, CH_2NH_2), 1.97-1.44 (4 H, m), 1.40-1.21 (4 H, m), 0.95 (3 H, t, CH_3)

A solution of 0.714 g of ethyl 3-(N-benzyloxycarbonylaminopropyl)-(1-hydroxybutyl)phosphinate in 10 ml of anhydrous dichloromethane at room temperature is treated with 0.712 g of N,N'-thiocarbonyl-diimidazole. The red solution is stirred for 20 hours at room temperature, diluted with dichloromethane and washed with cold 1.0M aqueous hydrochloric acid (2 x 30 ml), water and saturated aqueous sodium bicarbonate solution. The organic layer is dried and the solvent removed in vacuo to afford ethyl 3-(N-benzyloxycarbonylaminopropyl)-[1-(O-thiocarbonylimidaz-1-oyloxy)butyl]phosphinate as a pale yellow oil: $^1\text{H-NMR}$: δ (CDCl₃) 8.46 (1 H, d, t), 7.47 (1 H, d, t), 7.35 (5 H, m, Ph), 7.07 (1 H, m), 6.12 (1 H, m, CHO), 5.10 (2 H, CH₂Ph), 4.25-3.98 (2 H, m, CH₂OP), 3.25 (2 H, t, CH₂NH₂), 1.97-1.44 (2 H, m, 2 x CH₂), 1.42-1.20 (4 H, m), 0.96 (3 H, t, CH₃)

A solution of ethyl 3-(N-benzyloxycarbonylaminopropyl)-[1-(O-thiocarbonylimidaz-1-oyloxy)butyl]phosphinate in 10 ml of anhydrous degassed benzene is treated with 0.291 g of tri-n-butyltin hydride. The clear solution is brought to reflux and 0.08 g of azobisisobutyronitrile added. Reflux is continued for 1 hour after which time thin layer chromatography indicates the reaction to be complete. The reaction is cooled to room temperature and the volatile material removed in vacuo to afford a pale yellow oil. The oil is partitioned between acetonitrile/methane and the acetonitrile layer separated and washed with a further 2 x 20 ml hexane. Evaporation of the acetonitrile in vacuo and chromatography of the residual oil on silica gel affords ethyl 3-(N-benzyloxycarbonylaminopropyl)(n-butyl)phosphinate as an oil; saponification of this oil with lithium hydroxide followed by acidification with phosphoric acid affords 3-(N-benzyloxycarbonylaminoo)propyl(n-butyl)phosphinic acid, m.p. 116-118° described in example 3 yielding 3-aminopropyl(n-butyl)phosphinic acid, m.p. 231-234° (dec.).

Example 57:

Example 5: A mixture of 2.0 g ethyl 3-aminopropyl(1-hydroxybutyl)phosphinate and 20.0 ml 2 M aqueous hydrochloric acid is refluxed for 2 hours and then evaporated to dryness. The residual oil is dissolved in 10 ml of water, and re-evaporated. The residue is dissolved in 20 ml of ethanol and treated with propylene oxide and to give 1.5 g of 3-aminopropyl(1-hydroxybutyl)phosphinic acid, m.p. 188 °.

The starting material is prepared as follows:

A mixture of 24.5 g ethyl-(1,1-diethoxyethyl)phosphinate and 40 g of hexamethyldisilazane are heated at 148° under a inert gas for 3 hours. The reaction mixture is cooled to room temperature and 6 g of acrylonitrile is added. The mixture is stirred for 2 hours. The reaction mixture is evaporated, dissolved in aqueous methanol and re-evaporated to give 25.7 g of ethyl 2-cyanoethyl(1,1-diethoxyethyl)phosphinate (^{31}P -HMR: $\delta = \text{N} 44$ ppm).

This oil is treated with 25.7 g of trimethylsilyl chloride in 150 ml of commercial grade chloroform (containing 1 to 5 % b.w. of ethanol) at room temperature for 6 hours under argon. The reaction mixture is stripped, the oil is dissolved in methanol and re-evaporated to give ethyl 2-cyanoethylphosphinate.

A mixture of 2.5 g of ethyl 2-cyanoethylphosphinate of 4.96 g of hexamethyl disilazane is treated to 140° for 1 hour. The mixture is cooled to 50° and under 2,45 g of n-butyraldehyde are added. After 15 minutes to mixture is stripped to an oil which is co-evaporated with 10 ml of aqueous ethanol to give 3.7 g ethyl 2-cyanoethyl(1-hydroxybutyl)phosphinate. This oil is dissolved in 50 ml of ethanol containing 0.58 g of ammonium and 0.5 g of Raney Nickel and hydrogenated for 10 hours. The catalyst is filtered off and the solvent is removed by evaporation to give 2.0 g of ethyl 3-aminopropyl(1-hydroxybutyl-n-butyl)phosphinate

Example 58:

Example: A suspension of 1.23 g 3-aminopropylphosphorous acid in 25 ml of hexamethyldisilazane is heated to reflux under an inert gas for 20 hours. After this time a clear solution results and the reaction mixture is cooled to room temperature under inert gas and 50 ml of anhydrous acetone is added and an exothermic reaction results. The reaction mixture is allowed to cool to room temperature and the volatile components removed in vacuo to afford a clear oil. This oil is dissolved in 50 ml of a 2.0 M hydrochloric acid solution in water and washed with 2 x 100 ml of dichloromethane and 1 x 100 ml of ether. The aqueous layer is evaporated to dryness to give a semi-solid residue which is co-evaporated with water (10 x 20 ml) and absolute ethanol (10 x 20 ml) yielding 3-aminopropyl(2-hydroxyprop-2-yl)phosphinic acid hydrochloride m.p. 159-161° as a white solid. This is suspended in absolute ethanol and treated with propylene oxide. Filtration and drying of the solid affords 3-aminopropyl(2-hydroxyprop-2-yl)phosphinic acid; m.p. 243-244°.

Example 59:

In a manner analogous to that described (above) in Example 58 3-Aminopropyl-(1,2-dihydroxyprop-2-yl)phosphinic acid hydrochloride, m.p. 175-179° and 3-aminopropyl-(1,2-dihydroprop-2-yl)phosphinic acid, m.p. 209-210° (dec.) may be obtained by reaction with 1-0-tertbutyldimethylsilyloxyethyl propan-2-one at 70° for 20 hours.

The starting material may be obtained as follows:

To a solution of 6.8 g of imidazole in 20 ml of anhydrous dimethylformamide is added 7.5 g of tert-butyldimethylsilyl chloride in the same solvent at 10° under inert gas. The clear solution is stirred for 15 minutes at 10° before addition of 20 ml of an anhydrous dimethylformamide solution of 3.7 g of hydroxy acetone. A slight exothermic reaction ensues and the reaction mixture is warmed to room temperature and stirred for 16 hours. Subsequently the reaction mixture is diluted with ether and washed with water. After drying the organic phase with anhydrous magnesiumsulphate and removal of the ether in vacuo the clear oil is distilled to afford 1-0-tert-butyldimethylsilyloxy methyl propan-2-one; b.p. 84-85°/18 mm Hg.

Example 60:

In an analogous fashion to that described in Example 51, 3-amino-2-hydroxy-propyl(n-propyl)phosphinic acid and its hydrochloride can be prepared by reaction of n-propylphosphorous acid ethyl ester with epoxypropylphthalimid .

Example 61:

In a manner analogous to that described in Example 9, 3-amino-2-(p-chlorophenyl)-propyl(n-propyl)phosphinic acid and its hydrochloride can be prepared by reaction of n-propylphosphorous acid ethyl ester with 1-phthalimido-2-(p-chlorophenyl)-3-bromo-propane.

Example 62:

In a manner analogous to that described in Example 42, 3-amino-1-hydroxy-propyl(n-propyl)phosphinic acid and its hydrochloride can be prepared by reaction of 3-(benzyloxycarbonylamino)propanal with n-propylphosphorous acid ethyl ester.

Example 63:

In a manner analogous to that described in Example 32, 3-aminopropyl(4-hydroxybutyl)phosphinic acid and its hydrochloride can be obtained from the reaction of 3-aminopropylphosphorous acid and 4-hydroxybut-1-ene. Also, by the same method, 3-aminopropyl(3-hydroxybutyl)phosphinic acid and its hydrochloride can be obtained by reaction of 3-aminopropylphosphorous acid and 3-hydroxybut-1-ene.

Example 64:

In a manner analogous to that described in Example 9, 3-aminopropyl[2-(S)-methylbutyl]phosphinic acid, m.p. 252-255° (dec.) $[\alpha]_{365}^{20}$ nm = +20.5°; $[\alpha]_{436}^{20}$ nm = +13.8°; $[\alpha]_{546}^{20}$ = +8°; $[\alpha]_{578}^{20}$ = +6.6° and $[\alpha]_{589}^{20}$ = 6.1° (c = 0.95 in water) is obtained by reaction with (S)-(+) -2-methylbutyl iodide at 120°, 16 hours.

Example 65:

Preparation of 10,000 tablets each containing 100 mg of the active ingredient with a formula as follows:

3	3-amino-2-hydroxy-propyl(diethoxy-methyl)phosphinic acid	1,000.00 g
35	Lactose	257.00 g
	Corn starch	75.00 g
	Polyethylene glycol 6,000	75.00 g
40	Magnesium stearate	18.00 g
	Purified water	q.s.

Procedure:

All the powders are passed through a screen with openings of 0.6 mm. Then the drug substance, lactose, magnesium stearate and half of the starch are mixed to a suitable mixer. The other half of the starch is suspended in 40 ml of water and the suspension added to the boiling solution of the polyethylene glycol in 150 ml of water. The paste formed is added to the powders which are granulated, if necessary, with an additional amount of water. The granulate is dried overnight at 35°, broken on a screen with 1.2 mm openings and compressed into tablets with 12.8 mm diameter, uppers bisected.

Example 66:

Preparation of 10,000 capsules each containing 25 mg of the active ingredient with a formula as follows:

55	3-amino-2-hydroxypropyl(diethoxy-methyl)phosphinic acid	250.0 g
	Lactose	1,750.0 g

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Procedure:

All the powders are passed through a screen with openings of 0.6 mm. Then the drug substance is placed in a suitable mixer and mixed with the lactose until homogenous. No. 3 capsules are filled with 200 mg using a capsule filling machine.

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Example 67:

In a manner analogous to that described in Examples 65 and 66 tablets and capsules comprising as the active ingredients 10 - 100 mg of another compounds of the invention, e.g. as described in the Examples 1 to 64.

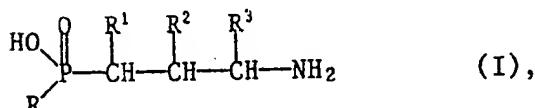
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Claims

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1. Compounds of the formula I

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wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy, and the remaining one of R¹, R² and R³ are hydrogen, provided that R is different from 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl if one of R¹, R² and R³ represents hydrogen, C₁-C₈-alkyl, C₃-C₆-cycloalkyl, phenyl optionally substituted by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl of C₇-C₁₀-phenylalkyl optionally substituted in the phenyl moiety by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl and the other two of R¹, R² and R³ are hydrogen, and to their salts, provided that salts of compounds of the formula I, wherein R denotes an unsubstituted aliphatic, cycloaliphatic or araliphatic hydrocarbon radical, R¹ and R³ denote hydrogen and R² is hydrogen or alkyl, with bases are different from alkali metal and ammonium salts.

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2. Compounds as claimed in claim 1, of the formula I, wherein R has 2 or more carbon atoms and denotes alkyl, alkenyl, alkynyl, alkyl or alkenyl substituted by halogen and/or hydroxy, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and substituted by halogen and/or hydroxy, cycloalkyl, cycloalkyl substituted by hydroxy, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl-lower alkyl, cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy or lower alkylthio and/or in the alkylene moiety by hydroxy, cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety, phenyl-lower alkyl, phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl and/or in the alkylene moiety by hydroxy or naphtyl-lower alkyl and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl or naphthyl, phenyl or naphthyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy and the remaining one of R¹, R² and R³ is hydrogen, and their salts.

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3. Compounds as claimed in claim 1, of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen, sulfur and cycloalkyl, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl or cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety; and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and their salts.

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4. Compounds as claimed in claim 1, of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, low r alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, lower alkanesulfanyl-lower alkyl, low r alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-low r alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, low r alkoxy-(halog no)lower alkyl, ph nyl-lower alkyl, phenyl-lower hydroxyalkyl, phenyl-lower alkyl or phenyl-lower hydroxyalkyl mono- or disubstituted d,

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in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, naphthyl-lower alkyl, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxa-, oxathia- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of R¹, R², R³ represents hydrogen, lower alkyl, cycloalkyl having 3 to 6 ring carbon atoms, phenyl, phenyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, ph nyl-low r alkyl or phenyl-lower alkyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and their salts.

5. Compounds as claimed in claim 1, of formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, phenyl-lower alkyl, phenyl-lower hydroxyalkyl, phenyl-lower alkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl or naphthyl-lower alkyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and their salts.

10. Compounds according to claim 3, of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl or lower alkynyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and their salts.

15. Compounds as claimed in claim 1, of the formula I, wherein R is represented by lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfinyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxa- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, provided that, if one of R¹ and R² is hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, and the other two of R¹, R² and R³ are hydrogen, R is different from hydroxy. R is different from 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl group, and their salts.

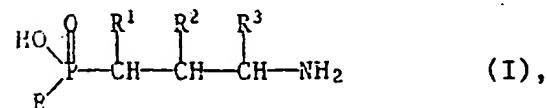
20. Compounds as claimed in claim 1, of the formula I, wherein R is C₂-C₁₂-alkyl, C₂-C₇-alkenyl, C₂-C₇-alkynyl, mono- or dihydroxy-C₂-C₇-alkyl, mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkyl, α -saturated mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkenyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, di-C₁-C₄-alkoxy-C₁-C₄-alkyl, α -hydroxy-C₃-C₆-cycloalkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₃-alkyl or 1-C₁-C₄-alkylthiocycloalkyl- α -hydroxy-C₁-C₄-alkyl, R² represents hydrogen, hydroxy, C₁-C₄-alkyl, phenyl or phenyl substituted by halogen or C₁-C₄-alkyl and R¹ and R³ are hydrogen or one of R¹ and R² denotes hydroxy and the other one as well as R³ represents hydrogen, and their salts.

25. Compounds as claimed in claim 1, of the formula I, wherein R denotes C₂-C₇-alkyl, α -saturated C₃-C₇-alkenyl, α -saturated C₃-C₇-alkynyl, α -, β -, γ - or δ -hydroxy-C₂-C₇-alkyl, α , β -dihydroxy-C₂-C₇-alkyl mono-, di- or trifluoro- α -hydroxy-C₃-C₇-alkyl, α -saturated mono-, di or trifluoro- α -hydroxy-C₃-C₇-alkenyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, α -hydroxy-C₃-C₆-cycloalkyl or C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₄-alkyl and R¹, R² and R³ represent hydrogen, and their salts.

30. Compounds according to claim 6, of formula I, wherein R is either C₂-C₇-alkyl, C₂-C₇-alkenyl, C₂-C₇-alkynyl or C₁-C₄-alkoxy-C₁-C₄-alkyl and R¹, R² and R³ are hydrogen, and their salts.

35. Compounds according to claim 6, of formula I, wherein R is C₃-C₇-alkyl and R¹, R² and R³ are hydrogen, and their salts.

40. Compounds of the formula I



65 wherein R is diethoxymethyl, one of R¹ and R² is p-chlorophenyl or methyl and R³ and the other one of R¹

and R² are hydrogen; or wherein R is a group of the formula -CH(OR')₂ in which R' represents C₁-C₄-alkyl and R¹, R² and R³ denote hydrogen, and their salts.

- 13. 3-Aminopropyl(n-butyl)phosphinic acid or a salt thereof.
- 14. 3-Aminopropyl(diethoxymethyl)phosphinic acid or a salt thereof.
- 15. 3-Aminopropyl(2-hydroxybutyl)phosphinic acid or a salt thereof.
- 16. 3-Aminopropyl(but-3-enyl)phosphinic acid or a salt thereof.
- 17. 3-Aminopropyl(isopentyl)phosphinic acid or a salt thereof.
- 18. 3-Aminopropyl(2-ethoxyethyl)phosphinic acid or a salt thereof.
- 19. 3-Aminopropyl(2-methylallyl)phosphinic acid or a salt thereof.
- 20. 3-Amino-2-(p-chlorophenyl)-propyl(diethoxymethyl)phosphinic acid, 10
3-amino-2-hydroxy-propyl(diethoxymethyl)phosphinic acid or
3-aminopropyl(n-propyl)phosphinic acid or a salt thereof.
- 21. 3-aminopropyl(isobutyl)phosphinic acid,
- 3-aminopropyl(n-pentyl)phosphinic acid,
- 3-aminopropyl(n-heptyl)phosphinic acid,
- 3-Aminopropyl(cyclopropylmethyl)phosphinic acid,
- 1-methyl-3-amino-propyl(n-butyl)phosphinic acid,
- 3-aminopropyl(pent-3-ynyl)phosphinic acid,
- 3-Aminopropyl(but-3-inyl)phosphinic acid,
- 3-aminopropyl(2-methylbutyl)-phosphinic acid,
- 3-aminopropyl-(3-ethoxypropyl)-phosphinic acid,
- 3-aminopropyl(3-methoxypropyl)phosphinic acid,
- 3-aminopropyl(but-2-ynyl)phosphinic acid,
- 3-aminopropyl[2-(2-ethoxyethoxy)ethyl]phosphinic acid,
- 3-aminopropyl(4,4,4-trifluorobutyl)phosphinic acid,
- 3-aminobutyl(diethoxymethyl)phosphinic acid,
- 3-aminopropyl(2-phenylethyl)phosphinic acid,
- 3-aminopropyl(dodecyl)phosphinic acid,
- 3-aminopropyl(benzyl)phosphinic acid,
- 3-aminopropyl(propargyl)-phosphinic acid,
- 3-aminopropyl(1-hydroxybutyl)phosphinic acid,
- 3-aminopropyl(1-hydroxyisobutyl)phosphinic acid,
- 3-aminopropyl(1-hydroxyethyl)phosphinic acid,
- 3-aminopropyl(1-hydroxybenzyl)phosphinic acid,
- 3-aminopropyl(1-hydroxy-4,4,4-trifluoro-butyl)phosphinic acid,
- 3-aminopropyl[1-hydroxy(Z)-2-fluoro-but-2-enyl]phosphinic acid,
- 3-aminopropyl(1-hydroxy-1-cyclopropylmethyl)phosphinic acid,
- 3-aminopropyl[1-hydroxy-1-(2-methylthiocyclopropyl)-methyl]phosphinic acid,
- 3-aminopropyl(cyclohexylmethyl)phosphinic acid,
- 3-aminopropyl(1-hydroxy-1-cyclobutyl-methyl)phosphinic acid,
- 3-aminopropyl[2-(R)hydroxy-3-methylbutyl]phosphinic acid,
- 3-aminopropyl(1,2-dihydroxyprop-2-yl)phosphinic acid,
- 3-amino-2-hydroxy-propyl(propyl)phosphinic acid,
- 3-amino-1-hydroxy-propyl(propyl)phosphinic acid,
- 3-aminopropyl(4-hydroxybutyl)phosphinic acid,
- 3-aminopropyl(3-hydroxybutyl)phosphinic acid or
- 3-aminopropyl(2-(S)-methylbutyl)phosphinic acid or a salt thereof.
- 22. 3-Amino-1-(p-chlorophenyl)-propyl(diethoxymethyl)phosphinic acid,
- 3-Aminopropyl(di-n-propyloxymethyl)phosphinic acid,
- 3-Aminopropyl(diisopropyloxymethyl)phosphinic acid,
- 3-Aminopropyl(di-n-butyloxymethyl)phosphinic acid or
- 3-Aminopropyl(tetrahydrofuran-2-yl)phosphinic acid or a salt thereof.
- 23. Compounds of the formula I

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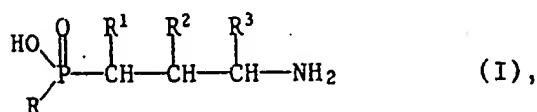
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wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of

R¹ and R², is hydroxy, and the remaining one of R¹, R² and R³ are hydrogen, and their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

24. Compounds according to claim 23 of the formula I, wherein R has 2 or more carbon atoms and denotes alkyl, alkenyl, alkynyl, alkyl or alkenyl substituted by halogen and/or hydroxy, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and substituted by halogen and/or hydroxy, cycloalkyl, cycloalkyl substituted by hydroxy, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl-lower alkyl, cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy or lower alkylthio and/or in the alkylene moiety by hydroxy, cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety, phenyl-lower alkyl or phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl and/or in the alkylene moiety by hydroxy or naphthyl-lower alkyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl or naphthyl, phenyl or naphthyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R² is hydroxy and the remaining one of R¹, R² and R³ is hydrogen, and their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

25. Compounds according to claim 23 of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfanyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower alkyl, phenyl-lower alkyl, phenyl-lower hydroxyalkyl, phenyl-lower alkyl or phenyl-lower hydroxyalkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, naphthyl-lower alkyl, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxo-, oxathia- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of R¹, R², R³ represents hydrogen, lower alkyl, cycloalkyl having 3 to 6 ring carbon atoms, phenyl, phenyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

26. Compounds according to claim 23 of formula I, wherein R denotes 1,1-di(C₁-C₄-alkoxy)-C₁-C₄-alkyl and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, phenyl or phenyl substituted by halogen or lower alkyl, and the remaining two of R¹, R² and R³ are hydrogen, and their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

27. Compounds according to claim 23 of formula I, wherein R denotes an aliphatic, cycloaliphatic or araliphatic hydrocarbon radical, R² represents hydrogen or alkyl and R¹ and R³ are hydrogen, in the form of a pharmaceutically acceptable alkali metal or ammonium salt for use for the treatment of the human or animal body.

28. Compounds according to claim 23 of the formula I, wherein R is C₂-C₁₂-alkyl, C₂-C₇-alkenyl, C₂-C₇-alkynyl, mono- or dihydroxy-C₂-C₇-alkyl, mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkyl, α -saturated mono-, di or trihalogeno- α -hydroxy-C₃-C₇-alkenyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, di-C₁-C₄-alkoxy-C₁-C₄-alkyl, α -hydroxy-C₃-C₆-cycloalkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₃-alkyl or 1-C₁-C₄-alkylthiocycloalkyl- α -hydroxy-C₁-C₄-alkyl, R² represents hydrogen, hydroxy, C₁-C₄-alkyl, phenyl or phenyl substituted by halogen, such as chloro, or C₁-C₄-alkyl and R¹ and R³ are hydrogen or one of R¹ and R² denotes hydroxy and the other one as well as R³ represents hydrogen, and their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

29. Compounds according to the claim 23 of the formula I, wherein R denotes di-C₁-C₄-alkoxy-C₁-C₄-alkyl, and R¹, R² and R³ represent hydrogen, and their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

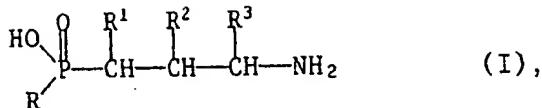
30. Compounds according to any one of claims 1, 2, 4, 5, 7-9, 12, 16-19 and 21-25, including their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

31. Compounds according to any one of claims 3, 6, 10, 11, 13, 14, 20, 26 and 29, including their pharmaceutically acceptable salts for use for the treatment of the human or animal body.

32. Pharmaceutical compositions containing, as the active ingredient, a compound according to any one of claims 1, 2, 4, 5, 7-9, 12, 16-19, 21-25, 27, 28 and 30 in admixture to a conventional pharmaceutical carrier system.

33. Pharmaceutical compositions containing, as the active ingredient, a compound according to any one of claims 3, 6, 10, 11, 13, 14, 20, 26, 29 and 31 in admixture to a conventional pharmaceutical carrier system.

34. A process for the manufacture of compounds of the formula I



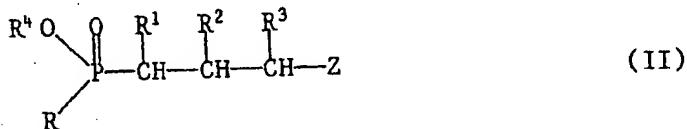
wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R² is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, provided that R is different from 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl if one of R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical and the other two of R¹, R² and R³ is hydrogen, and to their salts, provided that salts of compounds of the formula I, wherein R denotes an unsubstituted aliphatic, cycloaliphatic or araliphatic hydrocarbon radical, R¹ and R³ denote hydrogen and R² is hydrogen or alkyl, with bases are different from alkali metal and ammonium salts; and of their salts, characterized in that

a) in a compound of formula II

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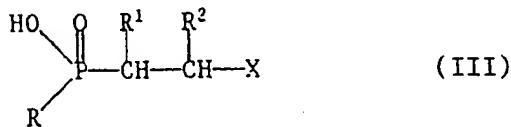
in which R, R¹ and R³ have their previous significances, Z represents -NH₂ and R⁴ denotes a hydroxy-protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl, denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen and/or any group Z⁰ is converted into -NH₂; or

b) in a compound of the formula III

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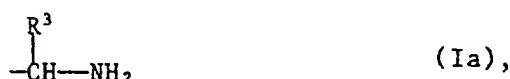
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in which R, R¹ and R² have their previous significances and X is a group capable of being converted into a group of formula -CH(R³)NH₂, the group X is converted into a group of formula

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wherein R³ has its previous significance; or

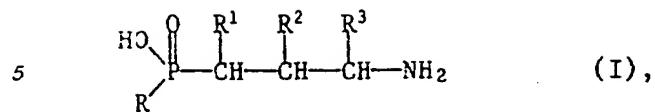
c) a compound of formula I', said compound of formula I' being otherwise identical to a compound of formula I but having one or more carbon-carbon-double bond(s) is reduced to produce a compound of formula I, and, if desired, a resulting salt obtained in this process may be converted into the free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual isomers.

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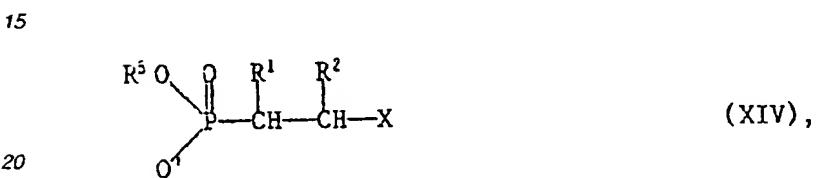
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35. A novel process for the manufacture of compounds of the formula I

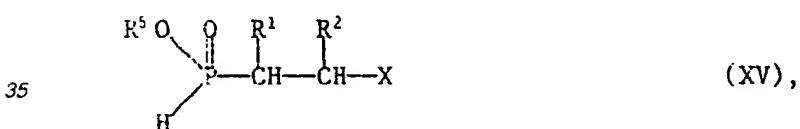
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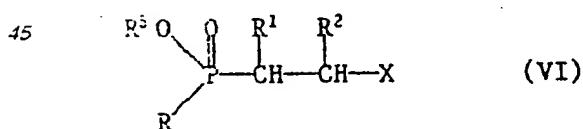
wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R² is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, and of their salts, characterised in that a compound of the formula



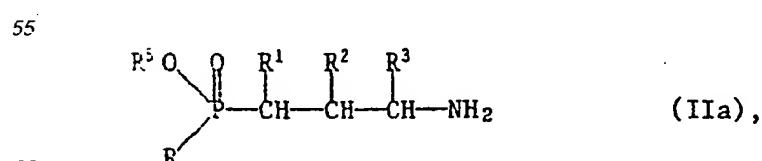
wherein R¹, R², and R⁵ having the meanings given hereinbefore, X denotes cyano, carbamoyl or a group of the formulae -CH(R³)-Z⁰ (XVa) or -C(R³)=Y (XVb) in which Z⁰ denotes a protected or latent amino group as specified hereinbefore, Y denotes an optionally acetalised, thioacetalised, ketalised or thioketalised oxo group and Q' denotes a group of the formula -C(R⁸)-C(OR⁹)(OR¹⁰) (XIVa) in which R⁸ denotes hydrogen or lower alkyl and R⁹ and R¹⁰, independently of one another, represent lower alkyl or together represent lower alkylene, is treated with an anhydrous protic medium, the resulting compound of the formula



wherein R¹, R², R⁵ and X have their previous significances is reacted with a compound of the formulae R'(CR'') = O (XIa), R'''-H (XIb) or R-Hal (XIc) wherein R, R', R'' and R''' have their previous significances, in the resulting compound of formula VI



50 wherein R¹, R², R⁵, R and X have their previous significances; the group X is converted into a group of formula -CH(R³)-Z⁰ and the resulting compound of formula Ila



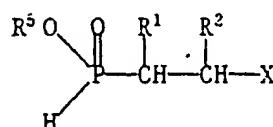
65 wherein R, R¹, R², R³ and R⁵ have their previous significances is converted into the corresponding compound of formula I and, if desired, a resulting salt obtained in this process may be converted into the free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual

isomers.

36. Process according to claim 35 for the manufacture of a compound according to anyone of claims 1 to 29 or of a salt thereof.

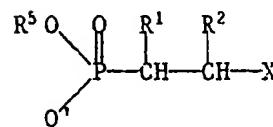
37. Use of a compound according to anyone of claims 1 to 31 as a nootropic, antidepressive and/or antiepileptic medicament or for the manufacture thereof.

38. A novel process for the manufacture of compounds of the formula



(XV),

wherein X denotes cyano, carbamoyl or a group of the formulae $-\text{CH}(\text{R}^3)\text{Z}^0$ (XVa) or $-\text{C}(\text{R}^3)=\text{Y}$ (XVb) in which Z^0 denotes a protected or latent amino group as specified hereinbefore, Y denotes an optionally acetalised, thioacetalised, ketalised or thioketalised oxo group, one of R^1 , R^2 and R^3 is hydrogen, hydroxy, $\text{C}_1\text{-C}_8$ -alkyl, $\text{C}_3\text{-C}_6$ -cycloalkyl, phenyl optionally substituted by halogen, $\text{C}_1\text{-C}_4$ -alkyl, $\text{C}_1\text{-C}_4$ -alkoxy and/or trifluoromethyl or is $\text{C}_7\text{-C}_{10}$ -phenylalkyl optionally substituted in the phenyl moiety by halogen, $\text{C}_1\text{-C}_4$ -alkyl, $\text{C}_1\text{-C}_4$ -alkoxy and/or trifluoromethyl and the others of R^1 , R^2 and R^3 are hydrogen, and R^5 denotes an aliphatic radical, characterised in that a compound of the formula



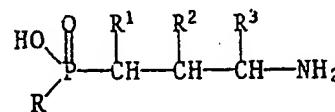
(XIV),

wherein R^1 , R^2 and R^5 and X have the meanings given hereinbefore and Q' denotes a group of the formula $-\text{C}(\text{R}^8)\text{-C}(\text{OR}^9)(\text{OR}^{10})$ (XIVa) in which R^8 denotes hydrogen or lower alkyl and R^9 and R^{10} , independently of one another, represent lower alkyl or together represent lower alkylene, is treated with an anhydrous protic medium.

39. Process according to claim 38, characterized in that ethyl 2-cyanoethyl(1-hydroxybutyl) phosphinate is manufactured.

Claims for the following Contracting State: GR

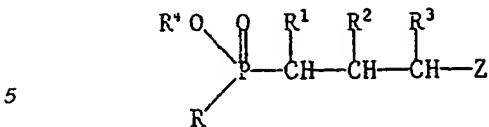
1. A process for the manufacture of compounds of the formula I



(I),

wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R^1 , R^2 and R^3 represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R^1 , R^2 and R^3 is hydrogen or, in the case of R^1 and R^2 is hydroxy, and the remaining one of R^1 , R^2 and R^3 is hydrogen, provided that R is different from 1,1-di($\text{C}_1\text{-C}_4$ -alkoxy)- $\text{C}_1\text{-C}_5$ -alkyl if one of R^1 , R^2 and R^3 represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical and the other two of R^1 , R^2 and R^3 is hydrogen, and to their salts, provided that salts of compounds of the formula I, wherein R denotes an unsubstituted aliphatic, cycloaliphatic or araliphatic hydrocarbon radical, R^1 and R^3 denote hydrogen and R^2 is hydrogen or alkyl, with bases are different from alkali metal and ammonium salts; and of their salts, characterized in that

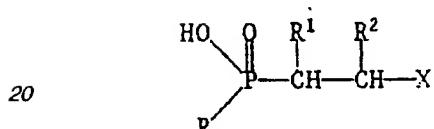
a) in a compound of formula II



(II)

10 in which R, R¹, R² and R³ have their previous significances, Z represents -NH₂ and R₄ denotes a hydroxy-protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl, denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen and/or any group Z⁰ is converted into -NH₂; or

15 b) in a compound of the formula III



(III)

25 in which R, R¹ and R² have their previous significances and X is a group capable of being converted into a group of formula -CH(R³)NH₂, the group X is converted into a group of formula



(Ia),

wherein R³ has its previous significance; or

35 c) a compound of formula I', said compound of formula I' being otherwise identical to a compound of formula I but having one or more carbon-carbon-double bond(s) is reduced to produce a compound of formula I, and, if desired, a resulting salt obtained in this process may be converted into the free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual isomers.

40 2. Process as claimed in claim 1 for the manufacture of compounds of the formula I, wherein R has 2 or more carbon atoms and denotes alkyl, alkenyl, alkynyl, alkyl or alkenyl substituted by halogen and/or hydroxy, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and substituted by halogen and/or hydroxy, cycloalkyl, cycloalkyl substituted by hydroxy, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl-lower alkyl, cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy or lower alkylthio and/or in the alkylene moiety by hydroxy, cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety, phenyl-lower alkyl, phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl and/or in the alkylene moiety by hydroxy or naphthyl-lower alkyl and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl or naphthyl, phenyl or naphthyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy and the remaining one of R¹, R² and R³ is hydrogen, and of their salts.

45 3. Process as claimed in claim 1 for the manufacture of compounds of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen, sulfur and cycloalkyl, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl or cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety; and wherein one of the groups R¹, R² and R³ represents hydrocarbon, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and of their salts.

4. Process as claimed in claim 1 for the manufacture of compounds of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, lower alkoxy-lower alkyl, lower alkylothio-lower alkyl, lower alkanesulfinyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower alkyl, phenyl-lower alkyl, phenyl-lower hydroxyalkyl, phenyl-lower alkyl or phenyl-lower hydroxyalkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, naphthyl-lower alkyl, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxo-, oxathia- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of R¹, R², R³ represents hydrogen, lower alkyl, cycloalkyl having 3 to 6 ring carbon atoms, phenyl, phenyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and of their salts.

5. Process as claimed in claim 1 for the manufacture of compounds of formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, phenyl-lower alkyl, phenyl-lower hydroxyalkyl, phenyl-lower alkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl or naphthyl-lower alkyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and of their salts.

6. Process according to claim 1 for the manufacture of compounds of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl or lower alkynyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, or one of R¹ and R² is hydroxy; and the remaining two of R¹, R² and R³ are hydrogen, and of their salts.

7. Process as claimed in claim 1 for the manufacture of compounds of the formula I, wherein R is represented by lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfinyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxo- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, provided that, if one of R¹ and R² is hydrogen, lower alkyl, cycloalkyl, phenyl, phenyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl lower alkyl or phenyl lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, and the other two of R¹, R² and R³ are hydrogen, R is different from hydroxy, R is different from 1,1-di(C₁-C₄-alkoxy)-C₁-C₅-alkyl group, and of their salts.

8. Process as claimed in claim 1 for the manufacture of compounds of the formula I, wherein R is C₂-C₁₂-alkyl, C₂-C₇-alkenyl, C₂-C₇-alkynyl, mono- or dihydroxy-C₂-C₇-alkyl, mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkyl, α -saturated mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkenyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, di-C₁-C₄-alkoxy-C₁-C₄-alkyl, α -hydroxy-C₃-C₆-cycloalkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₃-alkyl or 1-C₁-C₄-alkylthiocycloalkyl- α -hydroxy-C₁-C₄-alkyl, R² represents hydrogen, hydroxy, C₁-C₄-alkyl, phenyl or phenyl substituted by halogen or C₁-C₄-alkyl and R¹ and R³ are hydrogen or one of R¹ and R² denotes hydroxy and the other one as well as R³ represents hydrogen, and of their salts.

9. Process as claimed in claim 1 for the manufacture of compounds of the formula I, wherein R denotes C₂-C₇-alkyl, α -saturated C₃-C₇-alkyl, α -saturated C₃-C₇-alkynyl, α -, β -, γ - or δ -hydroxy-C₂-C₇-alkyl, α , β -dihydroxy-C₂-C₇-alkyl mono-, di- or trifluoro- α -hydroxy-C₃-C₇-alkyl, α -saturated mono-, di- or trifluoro- α -hydroxy-C₃-C₇-alkenyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, α -hydroxy-C₃-C₆-cycloalkyl or C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₄-alkyl and R¹, R² and R³ represent hydrogen, and of their salts.

10. Process according to claim 1 for the manufacture of compounds of formula I, wherein R is either C₂-C₇-alkyl, C₂-C₇-alkenyl, C₂-C₇-alkynyl or C₁-C₄-alkoxy-C₁-C₄-alkyl and R¹, R² and R³ are hydrogen,

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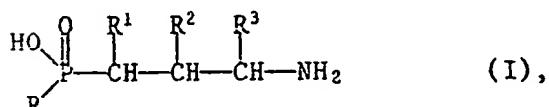
and of their salts.

11. Process according to claim 1 for the manufacture of compounds of formula I, wherein R is C₃-C₇-alkyl and R¹, R² and R³ are hydrogen, and of their salts.

12. Process for the manufacture of compounds of the formula I

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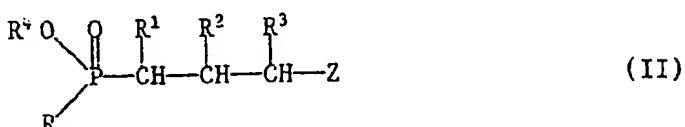


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wherein R is diethoxymethyl, one of R¹ and R² is p-chlorophenyl or methyl and R³ and the other one of R¹ and R² are hydrogen; or wherein R is a group of the formula -CH(OR')₂ in which R' represents C₁-C₄-alkyl and R¹, R² and R³ denote hydrogen, and their salts, characterized in that

a) in a compound of formula II

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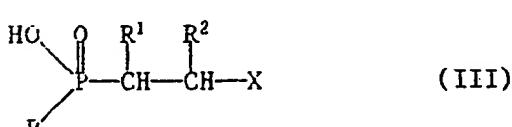
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in which R, R¹, R² and R³ have their previous significances, Z represents -NH₂ and R⁴ denotes a hydroxy-protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl, denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen and/or any group Z⁰ is converted into -NH₂; or

b) in a compound of the formula III

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in which R, R¹ and R² have their previous significances and X is a group capable of being converted into a group of formula -CH(R³)NH₂, the group X is converted into a group of formula

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wherein R³ has its previous significance; or

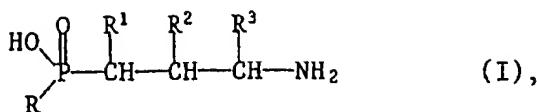
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c) a compound of formula I', said compound of formula I' being otherwise identical to a compound of formula I but having one or more carbon-carbon-double bond(s) is reduced to produce a compound of formula I, and, if desired, a resulting salt obtained in this process may be converted into the free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual isomers.

13. A novel process for the manufacture of compounds of the formula I

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wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R² is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, and of their salts, characterised in that a compound of the formula

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wherein R¹, R², and R⁵ have the meanings given hereinbefore, X denotes cyano, carbamoyl or a group of the formulae -CH(R³)-Z⁰ (XVa) or -C(R³)=Y (XVb) in which Z⁰ denotes a protected or latent amino group as specified hereinbefore, Y denotes an optionally acetalised, thioacetalised, ketalised or thioketalised oxo group and Q' denotes a group of the formula -C(R⁸)-C(OR⁹)(OR¹⁰) (XIVa) in which R⁸ denotes hydrogen or lower alkyl and R⁹ and R¹⁰, independently of one another, represent lower alkyl or together represent lower alkylene, is treated with an anhydrous protic medium, the resulting compound of the formula

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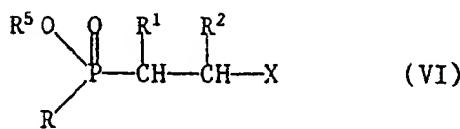


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wherein R¹, R², R⁵ and X have their previous significances is reacted with a compound of the formulae R'(CR'')=O (XIIa), R''-H (XIIb) or R-Hal (XIIc) wherein R, R¹, R'' and R''' have their previous significances, in the resulting compound of formula VI

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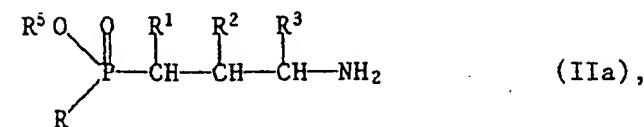
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wherein R¹, R², R⁵, R and X have their previous significances; the group X is converted into a group of formula -CH(R³)-Z⁰ and the resulting compound of formula IIa

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wherein R, R¹, R², R³ and R⁵ have their previous significances is converted into the corresponding compound of formula I and, if desired, a resulting salt obtained in this process may be converted into the

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free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual isomers.

14. Process according to claim 13 for the manufacture of compounds of the formula I, wherein R has 2 or more carbon atoms and denotes alkyl, alkenyl, alkynyl, alkyl or alkenyl substituted by halogen and/or hydroxy, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur and substituted by halogen and/or hydroxy, cycloalkyl, cycloalkyl substituted by hydroxy, cycloalkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur, cycloalkyl-lower alkyl, cycloalkyl-lower alkyl substituted in the cycloalkyl moiety by hydroxy or lower alkylthio and/or in the alkylene moiety by hydroxy, cycloalkyl-lower alkyl being interrupted by one or two mutually spaced atoms selected from oxygen and sulfur in the cycloalkyl moiety, phenyl-lower alkyl or phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl and/or in the alkylene moiety by hydroxy or naphthyl-lower alkyl, and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, cycloalkyl, phenyl or naphthyl, phenyl or naphthyl substituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl substituted in the phenyl moiety by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R² is hydroxy and the remaining one of R¹, R² and R³ is hydrogen, and of their salts.

15. Process according to claim 13 for the manufacture of compounds of the formula I, wherein R has 2 or more carbon atoms and is lower alkyl, lower alkenyl, lower alkynyl, a cycloalkyl, hydroxycycloalkyl, cycloalkyl-lower alkyl, cycloalkyl-(hydroxy)lower alkyl or lower alkylthiocycloalkyl-(hydroxy)lower alkyl group having 3 to 6 ring carbon atoms, mono- or dihydroxy-lower alkyl, hydroxy-lower alkenyl, mono-, di- or polyhalogeno-lower alkyl, mono-, di- or polyhalogeno-lower alkenyl, mono-, di- or polyhalogeno-(hydroxy)lower alkyl, mono-, di- or polyhalogeno-(hydroxy)lower alkenyl, lower alkoxy-lower alkyl, lower alkylthio-lower alkyl, lower alkanesulfanyl-lower alkyl, lower alkanesulfonyl-lower alkyl, di-lower alkoxy-lower alkyl, di-lower alkylthio-lower alkyl, lower alkoxy-(hydroxy)lower alkyl, lower alkoxy-(halogeno)lower alkyl, phenyl-lower alkyl, phenyl-lower hydroxylalkyl, phenyl-lower alkyl or phenyl-lower hydroxylalkyl mono- or disubstituted, in the phenyl moiety, by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, naphthyl-lower alkyl, oxa- or thiacycloalkyl having 2 to 6 ring carbon atoms, or dioxo-, oxathia- or dithiacycloalkyl having 3 to 5 ring carbon atoms, and wherein one of R¹, R², R³ represents hydrogen, lower alkyl, cycloalkyl having 3 to 6 ring carbon atoms, phenyl, phenyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, phenyl-lower alkyl or phenyl-lower alkyl mono- or disubstituted by halogen, lower alkyl, lower alkoxy and/or trifluoromethyl, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy; and the remaining one of R¹, R² and R³ is hydrogen, and of their salts.

16. Process according to claim 13 for the manufacture of compounds of formula I, wherein R denotes, 1,1-di(C₁-C₄-alkoxy)-C₁-C₄-alkyl, one of the groups R¹, R² and R³ represents hydrogen, or an aliphatic, cycloaliphatic, araliphatic or aromatic radical and the remaining two of R¹, R² and R³ are hydrogen, and of their salts.

17. Process according to claim 13 for the manufacture of compounds of formula I, wherein R denotes 1,1-di(C₁-C₄-alkoxy)-C₁-C₄-alkyl and wherein one of the groups R¹, R² and R³ represents hydrogen, lower alkyl, phenyl or phenyl substituted by halogen or lower alkyl, and the remaining two of R¹, R² and R³ are hydrogen, and of their salts.

18. Process according to claim 13 for the manufacture of compounds of the formula I, wherein R is C₂-C₁₂-alkyl, C₂-C₇-alkenyl, C₂-C₇-alkynyl, mono- or dihydroxy-C₂-C₇-alkyl, mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkyl, α -saturated mono-, di- or trihalogeno- α -hydroxy-C₃-C₇-alkenyl, C₁-C₄-alkoxy-C₁-C₄-alkyl, di-C₁-C₄-alkoxy-C₁-C₄-alkyl, α -hydroxy-C₃-C₆-cycloalkyl, C₃-C₆-cycloalkyl-C₁-C₄-alkyl, C₃-C₆-cycloalkyl- α -hydroxy-C₁-C₃-alkyl or 1-C₁-C₄-alkylthiocycloalkyl- α -hydroxy-C₁-C₄-alkyl, R² represents hydrogen, hydroxy, C₁-C₄-alkyl, phenyl or phenyl substituted by halogen, such as chloro, or C₁-C₄-alkyl and R¹ and R³ are hydrogen or one of R¹ and R² denotes hydroxy and the other one as well as R³ represents hydrogen, and of their salts.

19. Process according to claim 12 or 13 for the manufacture of compounds of the formula I, wherein R denotes di-C₁-C₄-alkoxy-C₁-C₄-alkyl, and R¹, R² and R³ represent hydrogen, and of their salts..

20. Process according to claim 1 or 13, wherein 3-aminopropyl(n-butyl)phosphinic acid or a salt thereof is manufactured.

21. Process according to claim 1 or 13, wherein 3-aminopropyl(2-hydroxybutyl)phosphinic acid or a salt thereof is manufactured.

22. Process according to claim 1 or 13, wherein 3-aminopropyl(but-3-enyl)phosphinic acid or a salt thereof is manufactured.

23. Process according to claim 1 or 13, wherein 3-aminopropyl(isopentyl)phosphinic acid or a salt thereof is manufactured.

24. Process according to claim 1 or 13, wherein 3-aminopropyl(2-ethoxyethyl)phosphinic acid or a salt thereof is manufactured.

25. Process according to claim 1 or 13, wherein 3-aminopropyl(2-methylallyl)phosphinic acid or a salt

thereof is manufactured.

26. Process according to claim 12 or 13, wherein 3-aminopropyl(diethoxymethyl)phosphinic acid or a salt thereof is manufactured.

27. Process according to claim 1 or 13, wherein

3-aminopropyl(n-propyl)phosphinic acid,

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3-aminopropyl(isobutyl)phosphinic acid,

3-aminopropyl(n-pentyl)phosphinic acid,

3-aminopropyl(cyclopropylmethyl)phosphinic,

1-methyl-3-amino-propyl(n-butyl)phosphinic acid,

3-aminopropyl(pent-3-ynyl)phosphinic acid,

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3-aminopropyl(but-3-inyl)phosphinic acid,

3-aminopropyl(2-methylbutyl)-phosphinic acid,

3-aminopropyl-(3-ethoxypropyl)-phosphinic acid,

3-aminopropyl(3-methoxypropyl)phosphinic acid,

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3-aminopropyl(but-2-inyl)phosphinic acid,

3-aminopropyl[2-(2-ethoxyethoxy)ethyl]phosphinic acid,

3-aminopropyl(4,4,4-trifluorobutyl)phosphinic acid,

3-amino-2-hydroxy-propyl(diethoxymethyl)phosphinic acid

3-aminobutyl(diethoxymethyl)phosphinic acid,

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3-aminopropyl(2-phenylethyl)phosphinic acid,

3-aminopropyl(dodecyl)phosphinic acid,

3-aminopropyl(benzyl)phosphinic acid,

3-aminopropyl(propargyl)-phosphinic acid,

3-aminopropyl(1-hydroxybutyl)phosphinic acid,

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3-aminopropyl(1-hydroxyisobutyl)phosphinic acid,

3-aminopropyl(1-hydroxyethyl)phosphinic acid,

3-aminopropyl(1-hydroxybenzyl)phosphinic acid,

3-aminopropyl(1-hydroxy-4,4,4-trifluoro-butyl)phosphinic acid,

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3-aminopropyl[1-hydroxy-(Z)-2-fluoro-but-2-enyl]phosphinic acid,

3-aminopropyl(1-hydroxy-1-cyclopropylmethyl)phosphinic acid,

3-aminopropyl[1-hydroxy-1-(2-methylthiocyclopropyl)-methyl]phosphinic acid,

3-aminopropyl(cyclohexylmethyl)phosphinic acid,

3-aminopropyl(1-hydroxy-1-cyclobutyl-methyl)phosphinic acid,

3-aminopropyl[2-(R)hydroxy-3-methylbutyl]phosphinic acid,

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3-aminopropyl(1,2-dihydroxyprop-2-yl)phosphinic acid,

3-amino-2-hydroxy-propyl(propyl)phosphinic acid,

3-amino-1-hydroxy-propyl(propyl)phosphinic acid,

3-aminopropyl(4-hydroxybutyl)phosphinic acid,

3-aminopropyl(3-hydroxybutyl)phosphinic acid or

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3-aminopropyl(2-(S)-methylbutyl)phosphinic acid or a salt thereof is manufactured.

28. Process according to claim 12 or 13, wherein

3-amino-2-(p-chlorophenyl)-propyl(diethoxymethyl)phosphinic acid,

3-amino-1-(p-chlorophenyl)-propyl(diethoxymethyl)phosphinic acid,

3-aminopropyl(di-n-propyloxymethyl)phosphinic acid,

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3-aminopropyl(diisopropyloxymethyl)phosphinic acid or

3-aminopropyl(di-n-butyloxymethyl)phosphinic acid or a salt thereof is manufactured.

29. Process for the manufacture of pharmaceutical compositions, wherein a compound obtainable according to any one of claims 1 to 28 is admixed to a conventional pharmaceutical carrier system.

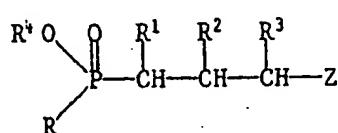
30. Process for the manufacture of nootropic, antidepressive and/or anti-epileptic medicaments, characterised in that a compound according to anyone of claims 1-28 is admixed to conventional pharmaceutical carriers.

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31. Process for the manufacture of nootropic, antidepressive and/or anti-epileptic medicaments, characterised in that

a) in a compound of formula II

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(II)

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In which R, R¹, R² and R³ have their previous significances, Z represents -NH₂ and R⁴ denotes a hydroxy-protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl,

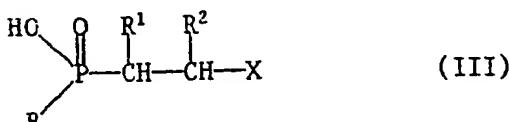
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denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen and/or any group Z⁰ is converted into -NH₂; or

b) in a compound of the formula III

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in which R, R¹ and R² have their previous significances and X is a group capable of being converted into a group of formula -CH(R³)NH₂, the group X is converted into a group of formula

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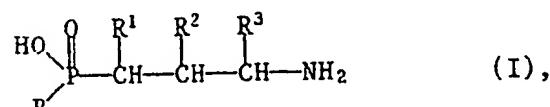
wherein R³ has its previous significance; or

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c) a compound of formula I', said compound of formula I' being otherwise identical to a compound of formula I but having one or more carbon-carbon-double bond(s) is reduced to produce a compound of formula I, and, if desired, a resulting salt obtained in this process may be converted into the free compound or into another salt and/or, if desired, a resulting free compound is converted into a salt to suit the above definition and/or, if desired, a resulting mixture of isomers is separated into the individual isomers and the resulting compound of the formula I

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wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R² is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen or a pharmaceutically acceptable salt thereof is admixed to conventional pharmaceutical carriers.

32. A novel process for the manufacture of compounds of the formula

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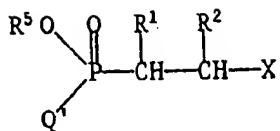
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wherein X denotes cyano, carbamoyl or a group of the formulae -CH(R³)-Z⁰ (XVa) or -C(R³)=Y (XVb) in which Z⁰ denotes a protected or latent amino group as specified hereinbefore, Y denotes an optionally acetalised, thioacetalised, ketalised or thioketalised oxo group, one of R¹, R² and R³ is hydrogen, hydroxy, C₁-C₈-alkyl, C₃-C₆-cycloalkyl, phenyl optionally substituted by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl or is C₇-C₁₀-phenylalkyl optionally substituted in the phenyl moiety by halogen, C₁-C₄-alkyl, C₁-C₄-alkoxy and/or trifluoromethyl and the others of R¹, R² and R³ are hydrogen, and R⁵ denotes an aliphatic radical, characterised in that a compound of the formula



(XIV),

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wherein R¹, R², R⁵ and X have the meanings given hereinbefore and Q' denotes a group of the formula -C(R⁸)-C(OR⁹)(OR¹⁰) (XIVa) in which R⁸ denotes hydrogen or lower alkyl and R⁹ and R¹⁰, independently of one another, represent lower alkyl or together represent lower alkylene, is treated with an anhydrous protic medium.

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33. Process according to claim 32, characterized in that ethyl 2-cyanoethyl(1-hydroxybutyl) phosphinate is manufactured.

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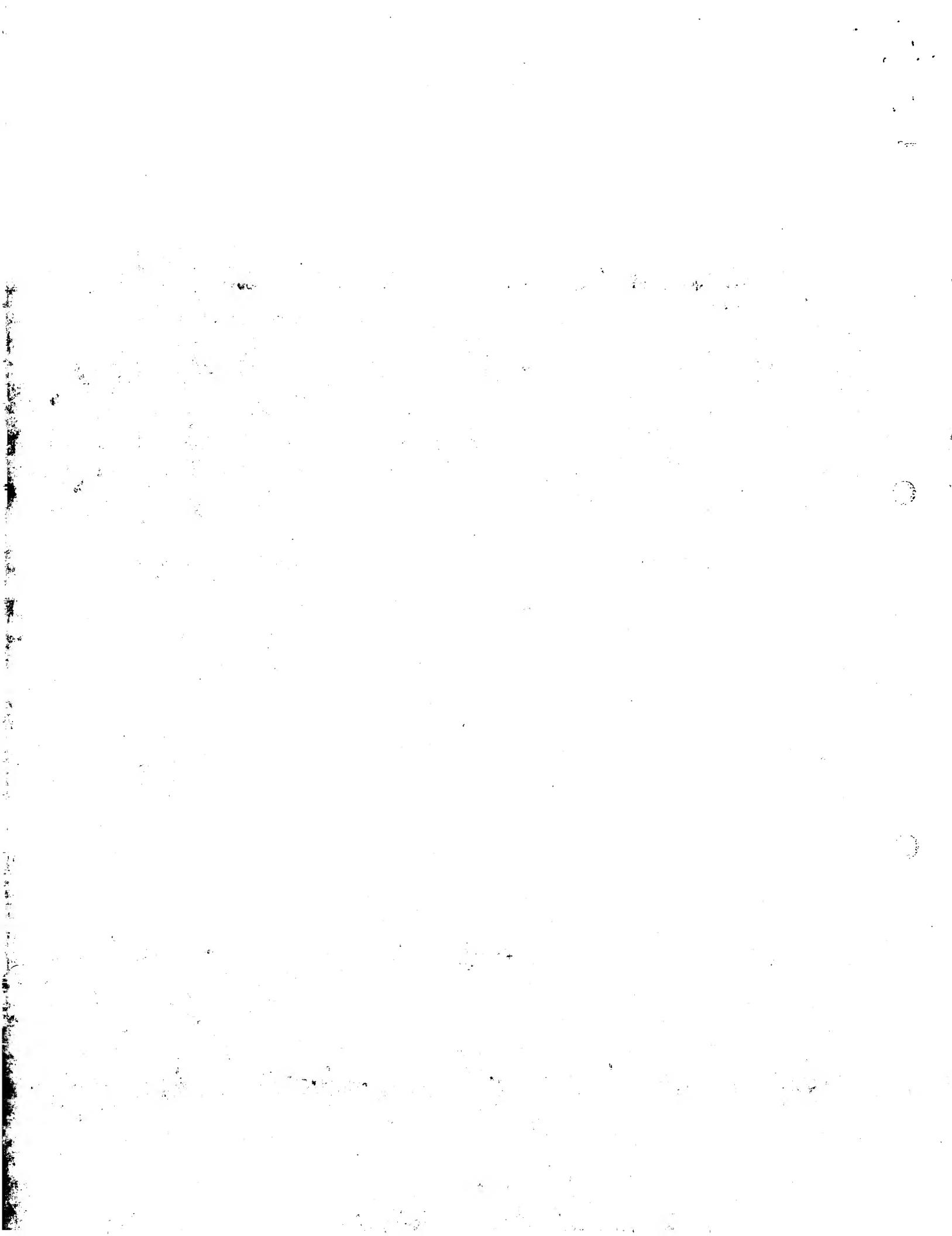
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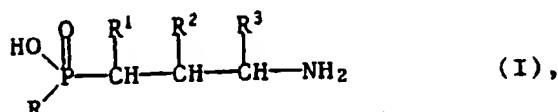
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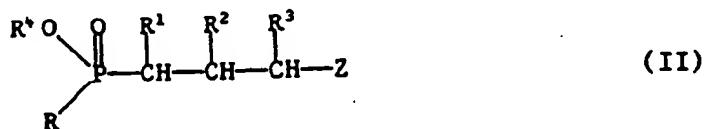
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(54) Substituted propane-phosphinic acid compounds.

(57) Compounds of the formula I



wherein R denotes an aliphatic, cycloaliphatic, cycloaliphatic-aliphatic or araliphatic radical having 2 or more carbon atoms, and wherein one of the groups R¹, R² and R³ represents hydrogen or an aliphatic, cycloaliphatic, araliphatic or aromatic radical, another one of R¹, R² and R³ is hydrogen or, in the case of R¹ and R², is hydroxy, and the remaining one of R¹, R² and R³ is hydrogen, and their salts have GABA_B-antagonistic properties and can be used as GABA_B-antagonists. They are obtained when in a compound of formula II



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in which R, R¹, R² and R³ have their previous significances, Z represents -NH₂ and R⁴ denotes a hydroxy-

protective group R⁵ or, when R¹ and R³ denote hydrogen and R² denotes hydrogen or alkyl, denotes an alkali metal or ammonium ion R⁶, or Z represents a protected or latent amino group Z⁰ and R⁴ denotes hydrogen or a hydroxy-protective group R⁵, any group R⁵ or R⁶ is replaced by hydrogen, and/or any group Z⁰ is converted into -NH₂.



European Patent
Office

EUROPEAN SEARCH REPORT

Application Number

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DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 4)
A	FR-A-2 282 431 (HOECHST) * The whole patent * ----	1	C 07 F 9/30 C 07 F 9/48 A 61 K 31/66
A	EP-A-0 181 833 (CIBA GEIGY) * Claims * -----	1	
TECHNICAL FIELDS SEARCHED (Int. Cl.4)			
C 07 F 9/00 A 61 K 31/00			
The present search report has been drawn up for all claims			
Place of search	Date of completion of the search	Examiner	
THE HAGUE	03-04-1990	OUSSET J-B.	
CATEGORY OF CITED DOCUMENTS		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document	
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